

Forces between chemically structured substrates mediated by critical fluids

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We consider binary liquid mixtures close to their critical points confined by two parallel, geometrically flat but chemically structured, substrates. Universal order parameters profiles are calculated within mean field theory for periodic patterns of stripes with alternating preferences for the two species of the mixture and with different relative positions of the two substrates. From the order parameters profiles the effective forces between the two plates are derived. The tuning of Casimir amplitudes is discussed.

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I. INTRODUCTION

Since chemical structuring of surfaces in the μm -range and below have become feasible, e.g., via self-assembled monolayers (SAM) of block-copolymers or mixtures of polymers,^{1,2,3} micro-contact printing,^{4,5} or exposure through a mask of photosensitive surfaces or surfaces which change their properties after irradiation,^{6,7,8,9} chemically patterned substrates have gained both practical and theoretical interest. Chemically structured substrates have applications in micro-reactors, the laboratory on the chip, and in chemical sensors.^{10,11} For these systems the local properties of fluids as confined by structured walls play an important role. In turn, wetting^{12,13,14,15} as well as critical adsorption of fluids¹⁶ at chemically structured substrates are in the focus of theoretical studies, the latter being the basis for the present analysis. While the above studies deal with a bulk phase in contact with a single substrate one is also interested in thin films confined between two substrates. Examples are liquids confined in (slit) pores or thin – albeit still large on the microscopic scale – wetting films for which the vapor phase plays the role of the second substrate. For instance there are studies of confined liquid crystals,¹⁷ confined block copolymers,^{18,19,20,21} and spherical particles with attractive interactions confined between two structured substrates.^{22,23,24,25,26,27}

If a fluid confined between two plates is brought close to its critical point, an effective force arises acting on the walls due to the boundary conditions imposing a restriction on the spectrum of the critical order parameter fluctuations. Since this force has a similar origin as the Casimir force between two conducting plates discovered by Casimir in 1948,²⁸ this force is called critical Casimir force and was first predicted by Fisher and de Gennes²⁹ and is described by universal scaling functions.^{30,31,32} For fluids confined between two *homogeneous* substrates providing symmetry breaking boundary conditions the universal scaling function of the critical Casimir force can be calculated analytically within mean field theory.³³ The Casimir forces due to director fluctuations in liquid crys-

tals confined between a patterned and a homogeneous substrate have been recently studied within Gaussian approximation.³⁴ Here we focus on the *universal* features of the force generated by binary liquid mixtures close to their critical point and confined between two chemically inhomogeneous substrates with laterally varying preferences for the two species of the binary mixture. Within mean field theory we calculate numerically the order parameter profiles and fully take into account the effect of critical adsorption.^{16,35}

The article is organized as follows: In Sec. II we recall some basic aspects of critical forces between homogeneous substrates in order to set the stage for the investigation of the effective forces emerging between inhomogeneous substrates in Sec. III. In Subsecs. III B and III C we study two substrates exhibiting the same and opposite patterns, respectively, while in Subsec. III D we investigate the forces between one structured and one homogeneous substrate. After the comparison of these different cases in Subsec. III E, we conclude in Subsec. III F with the study of the normal and lateral forces appearing between two substrates as function of the misalignment of their surface structures. In Sec. IV we summarize our results.

II. EFFECTIVE FORCES BETWEEN HOMOGENEOUS SUBSTRATES

A. Surface universality classes

Binary liquid mixtures near their critical point of demixing belong to the so-called Ising universality class which also contains one-component (and multi-component) liquids near their liquid-vapor critical point and uniaxial ferromagnets near the Curie point. In this sense in the following we refer to binary liquid mixtures without loss of generality. Surfaces endow confined systems of a given bulk universality class with a fine structure of surface universality classes as far as their surface critical behavior is concerned. They are characterized within renormalization group theory by the surface enhancement c and the

surface field h_1 . Accordingly, the bulk Ising universality class splits up into three surface universality classes.^{35,36} The parameter set ($h_1 = 0, c > 0$) characterizes the so-called ordinary surface universality class for which the order parameter at the surface is suppressed below its bulk value. For magnetic systems this is the generic case. ($h_1 = 0, c = 0$) describes (within mean field theory) the so-called special surface universality class with a multicritical point at which the confined system undergoes simultaneously a phase transition in the bulk and at the surface. For ($h_1 = 0, c < 0$) the system belongs to the so-called extraordinary surface universality class for which the order parameter is larger at the surface than in the bulk even above the critical temperature for which the bulk order parameter vanishes. This is rather uncommon for magnetic systems mirroring the choice of the name. In contrast, for fluid systems an enhanced order parameter relative to the bulk value is the generic case such that this surface universality class is then called normal surface universality class which is defined by ($|h_1| > 0, c = 0$). The normal and the extraordinary surface universality class are equivalent and identical at their fixed points, ($|h_1| \rightarrow \infty, c = 0$) for fluid systems and ($h_1 = 0, c \rightarrow -\infty$) for magnetic systems, and thus exhibit the same leading asymptotic critical behavior.^{39,40} In the following we shall focus on binary liquid mixtures close to their bulk critical demixing temperature T_c and exposed to substrates with strong surface fields as representatives of the normal surface universality class. Our results equally hold for systems at the fixed point of the extraordinary surface universality class.

B. Scaling of the film free energy and the solvation force

The free energy Ω_{tot} of a binary liquid mixture confined between two parallel planar homogeneous substrates of macroscopic area A which are separated by a distance L and characterized by a surface field h_1 and h_2 , respectively, and a surface enhancement c_1 and c_2 , respectively, consists of a nonsingular, i.e., analytic background contribution Ω_{ns} and a part Ω with a singular dependence on temperature:

$$\begin{aligned} \Omega_{tot}(t, L, h_1, h_2, c_1, c_2) \\ = \Omega_{ns}(t, L, h_1, h_2, c_1, c_2) + \Omega(t, L, h_1, h_2, c_1, c_2). \end{aligned} \quad (1)$$

We consider the case $t = (T - T_c)/T_c \rightarrow 0^\pm$ and $L \gg$ atomic length scales for which Ω is expected to exhibit universal behavior. Since we focus on the fixed point behavior ($h_1 \rightarrow \pm\infty, c = 0$), the dependences on c_1, c_2, h_1 and h_2 drop out from Ω .

Both contributions to the free energy decompose into four distinct contributions:

$$\frac{\Omega(L)}{A} = L\omega_b + \omega_{s,1} + \omega_{s,2} + \omega(L). \quad (2)$$

The term ω_b is the bulk free energy density and $\omega_{s,1}$ and $\omega_{s,2}$ are the surface free energies per surface area A of semi-infinite systems bounded by the surface S_1 and S_2 , respectively. The finite-size contribution $\omega(L)$ vanishes in the limit $L \rightarrow \infty$ unless opposing boundary conditions create an interface in the middle of the film. Concerning this decomposition near T_c see, e.g., Refs. 30,31,41; ω_b is independent of boundary conditions, $\omega_{s,i}$ depends on the boundary condition at S_i only, and ω depends on *both* boundary conditions. Near T_c the singular contributions exhibit the following scaling behaviors:

$$\frac{\omega_b(t)(\xi_0^\pm)^d}{k_B T_c} = \frac{a_b^\pm}{\alpha(1-\alpha)(2-\alpha)} |t|^{2-\alpha} \quad (3)$$

and

$$\frac{\omega_{s,i}(t)(\xi_0^\pm)^{d-1}}{k_B T_c} = \frac{a_{s,i}^\pm}{\alpha_s(1-\alpha_s)(2-\alpha_s)} |t|^{2-\alpha_s}, \quad (4)$$

$i = 1, 2,$

where α is the critical exponent of the bulk specific heat and $\alpha_s = \alpha + \nu$ is the critical exponent of the surface specific heat, $\xi_0^\pm$ are the non-universal amplitudes of the bulk correlation length $\xi^\pm(t \rightarrow 0^\pm) = \xi_0^\pm |t|^{-\nu}$, $a_b^\pm$ are universal bulk amplitudes, and $a_s^\pm$ are universal surface amplitudes.

Using the hyper-scaling relation $2 - \alpha = d\nu$ ^{36,42} the singular part of the film free energy can be rewritten as

$$\begin{aligned} \frac{\Omega}{k_B T_c A} &= \frac{1}{L^{d-1}} \left\{ \frac{a_b^\pm}{\alpha(1-\alpha)(2-\alpha)} (\tilde{L}^\pm)^d \right. \\ &\quad \left. + \frac{a_{s,1}^\pm + a_{s,2}^\pm}{\alpha_s(1-\alpha_s)(2-\alpha_s)} (\tilde{L}^\pm)^{d-1} + \Theta^\pm(\tilde{L}^\pm) \right\} \\ &= \frac{1}{L^{d-1}} Y(\tilde{L}^\pm), \quad \tilde{L}^\pm = \frac{L}{\xi^\pm}, \end{aligned} \quad (5)$$

where $\Theta^\pm(\tilde{L}^\pm)$ denote the universal scaling functions of the finite-size contribution. Since the critical point of the film is shifted to a temperature below T_c of the bulk, Y is an analytic function at T_c and thus exhibits the Taylor expansion

$$Y(\tilde{L}^\pm \rightarrow 0) = \sum_{i=0}^{\infty} \Delta_i^\pm(h_1 = \pm\infty, h_2 = \pm\infty) (\tilde{L}^\pm)^{\frac{i}{\nu}}. \quad (6)$$

In the case of boundary conditions $h_1 = +\infty, h_2 = -\infty$ the analogue of the bulk critical point in the film is completely eliminated (see, e.g., Ref. 43 and references therein). Apart from the spatial dimensions and the dimensionality of the order parameter the universal coefficients $\Delta_i^\pm$ depend on the boundary conditions applied at both substrates. In Eq. (6) the coefficients of zeroth order $\Theta^\pm(0) = \Delta_0^\pm(h_1 = \pm\infty, h_2 = \pm\infty) = \Delta^{++}$ and $\Theta^\pm(0) = \Delta_0^\pm(h_1 = \pm\infty, h_2 = \mp\infty) = \Delta^{+-}$ are called Casimir amplitudes so that at T_c the finite size contribution to the free energy scales as

$$\frac{\omega(L)}{k_B T_c} = L^{-(d-1)} \Delta, \quad T = T_c, \quad \Delta = \Delta^{++}, \Delta^{+-}. \quad (7)$$

The solvation force $F_{tot}(t, L)$ between the substrates is given by $F_{tot} = -\frac{\partial \Omega_{tot}}{\partial L}$. Like the free energy it splits up into a nonsingular background F_{ns} and a singular part $F(t, L)$. The singular part exhibits the scaling behavior

$$\frac{F(t, L)}{k_B T_c A} \equiv f_{\perp,0}(t, L) = (d-1) L^{-d} \tilde{f}_{\perp,0}^{\pm}(\tilde{L}^{\pm}), \quad (8)$$

with the universal scaling function

$$\begin{aligned} & (d-1) \tilde{f}_{\perp,0}^{\pm}(\tilde{L}^{\pm}) \\ &= - \left\{ \frac{a_b^{\pm}}{\alpha(1-\alpha)(2-\alpha)} (\tilde{L}^{\pm})^d + \tilde{L}^{\pm} \frac{d}{d\tilde{L}^{\pm}} \Theta^{\pm}(\tilde{L}^{\pm}) \right. \\ & \quad \left. - (d-1) \Theta^{\pm}(\tilde{L}^{\pm}) \right\}. \end{aligned} \quad (9)$$

In the view of the analysis following later the index 0 indicates that homogeneous substrates with no lateral structure are considered. One general property of the scaling function $\tilde{f}_{\perp,0}^{\pm}$ of the force is that for $T \neq T_c$ it vanishes exponentially for $L \rightarrow \infty$:^{30,31,32,33}

$$\tilde{f}_{\perp,0}^{\pm}(\tilde{L}^{\pm} \rightarrow \infty) \sim e^{-\tilde{L}^{\pm}}. \quad (10)$$

At T_c the force is determined by the Casimir amplitude:

$$f_{\perp,0}(t=0, L) = (d-1) L^{-d} \Delta_0, \quad (11)$$

$$\Delta_0 = \Delta_0^{++}, \Delta_0^{+-}.$$

The index 0 indicates the case of homogeneous substrates.

C. Scaling of the order parameter

For laterally homogeneous surfaces S_1 and S_2 the order parameter ϕ depends on the normal distance z from the surface $z=0$ and exhibits the following scaling properties:^{35,36,44,45}

$$\begin{aligned} \phi(t, z, L) &= a |t|^{\beta} P^{\pm}(w^{\pm}, \tilde{L}^{\pm}), \quad w^{\pm} = \frac{z}{\xi^{\pm}}, \quad \tilde{L}^{\pm} = \frac{L}{\xi^{\pm}} \\ &= a \left(\frac{L}{\xi_0^{\pm}} \right)^{-\frac{\beta}{\nu}} \hat{P}^{\pm} \left(\frac{z}{L}, \tilde{L}^{\pm} \right) \end{aligned} \quad (12)$$

with $\hat{P} = \left(\tilde{L}^{\pm} \right)^{\frac{\beta}{\nu}} P^{\pm}$ and a as the non-universal amplitude of the bulk order parameter. For increasing separation of the substrates the half-space fixed point scaling function $P_{\infty}^{\pm}(w^{\pm})$ is attained:

$$P^{\pm}(w^{\pm}, \tilde{L}^{\pm} \rightarrow \infty) \rightarrow P_{\infty}^{\pm}(w^{\pm}). \quad (13)$$

For a fixed scaled separation $\tilde{L}^{\pm}$ of the two substrates the scaling function behaves as:

$$P^{\pm}(w^{\pm} \rightarrow 0, \tilde{L}^{\pm}) \sim (w^{\pm})^{-\frac{\beta}{\nu}} \quad (14)$$

and

$$P^{\pm}(w^{\pm} \rightarrow \tilde{L}^{\pm}, \tilde{L}^{\pm}) \sim (\tilde{L}^{\pm} - w^{\pm})^{-\frac{\beta}{\nu}}. \quad (15)$$

The half-space fixed point scaling function decays exponentially towards its bulk value $P_b^{\pm}$:

$$P_{\infty}^{\pm}(w^{\pm} \rightarrow \infty) - P_b^{\pm} \sim e^{-w^{\pm}}, \quad (16)$$

where $P_b^{+} = 0$ and $P_b^{-} = 1$.

D. Mean field theory

In the spirit of a systematic field theoretical renormalization group approach the scaling functions introduced above can be determined in lowest order perturbation theory, i.e., within mean field theory corresponding to $\epsilon = 4 - d = 0$. The scaling variables entering into the scaling functions are used with their full scaling form for $\epsilon = 1$. This approach can be extended also to the case of laterally inhomogeneous confining substrates which leads to analogous scaling functions with an enlarged set of scaling variables. To this end we consider the fixed point Hamiltonian $\mathcal{H}[\phi]$ which is a functional of the order parameter profile $\phi(z)$. For binary liquid mixtures undergoing demixing it describes the local deviation of the concentration from the critical concentration in the bulk. The dimensionless fixed point Hamiltonian $\mathcal{H}[\phi] = \mathcal{H}_b[\phi] + \mathcal{H}_s[\phi]$ (providing the statistical weight $e^{-\mathcal{H}[\phi]}$ for the order parameter ϕ) separates into the bulk part $\mathcal{H}_b[\phi]$ confined to the volume $V = AL$ and the surface part $\mathcal{H}_s[\phi]$ at the two surfaces with area A .^{35,36}

$$\mathcal{H}_b[\phi] = \int_V d^{d-1} \mathbf{r}_{\parallel} \int_0^L dz \left(\frac{1}{2} (\nabla \phi)^2 + \frac{\tau}{2} \phi^2 + \frac{u}{4!} \phi^4 \right), \quad (17)$$

$$\mathcal{H}_s[\phi] = \int_A d^{d-1} \mathbf{r}_{\parallel} (-h_1 \phi(z=0) - h_2 \phi(z=L)). \quad (18)$$

Here $\mathbf{r}_{\parallel}$ is a vector parallel to the substrates, z indicates the direction perpendicular to the substrate, and d denotes the spatial dimension of the system. τ is proportional to the reduced temperature $t = \frac{T-T_c}{T_c}$, the coupling constant $u > 0$, which is dimensionless for $d=4$, stabilizes the Hamiltonian $\mathcal{H}[\phi]$ for temperatures below the critical point ($T < T_c$), and $(\nabla \phi)^2$ penalizes spatial variations; h_1 and h_2 denote the surface fields for the substrate at $z=0$ and at $z=L$. Accordingly, the Lagrange density $\mathcal{L}_b[\phi]$ corresponding to the bulk part $\mathcal{H}_b[\phi] = \int dV \mathcal{L}_b[\phi]$ of the Hamiltonian reads:

$$\mathcal{L}_b[\phi] = \frac{1}{2} (\nabla \phi)^2 + \frac{\tau}{2} \phi^2 + \frac{u}{4!} \phi^4. \quad (19)$$

The functional form of the Lagrange density $\mathcal{L}_s[\phi]$ of the surface part $\mathcal{H}_s[\phi]$ is independent of L and leads to the boundary conditions, c.f., in Eqs. (22) and (23).

Within mean field approximation fluctuations of the order parameter profile are neglected and only the configuration m of the order parameter profile with the largest statistical weight $e^{-\mathcal{H}[\phi]}$ is taken into account. This mean field solution m of the order parameter profile is determined by

$$\left. \frac{\delta \mathcal{H}[\phi]}{\delta \phi} \right|_{\phi=m} = 0. \quad (20)$$

For a system confined between two parallel homogeneous substrates Eqs. (17)-(20) lead to a differential equation for the mean field profile $m(z)$ of the order parameter^{35,36}

$$-\partial_z^2 m + \tau m + \frac{u}{3!} m^3 = 0, \quad (21)$$

with boundary conditions

$$\partial_z m|_{z=0} = -h_1 \quad (22)$$

and

$$\partial_z m|_{z=L} = +h_2. \quad (23)$$

E. Calculation of the force from the free energy

The effective force acting on the two parallel plates is the negative derivative of the free energy of the system with respect to the distance L between the substrates. If this force between the substrates is calculated numerically from the difference in the mean field free energies of the systems with separation L and $L + \Delta L$ between the substrates, numerical problems may arise due to the diverging contributions to the free energy from the surfaces for surface fields $h_{1,2} \rightarrow \pm\infty$ (see, c.f., Eq. (24)).

For systems confined between two parallel homogeneous substrates with boundary conditions (22) and (23) the free energy of the system per area A and per $k_B T_c$ can be expressed in terms of the order parameter profile:³³

$$\begin{aligned} \frac{\Omega[m]}{k_B T_c A} = & -\frac{2}{3} h_1 m(0) - \frac{2}{3} h_2 m(L) \\ & + \frac{L}{3} \left[\frac{1}{2} (\partial_z m|_{z_0})^2 - \frac{\tau}{2} m(z_0)^2 - \frac{u}{4!} m(z_0)^4 \right], \end{aligned} \quad (24)$$

where $0 \leq z_0 \leq L$ denotes an arbitrarily chosen point between the two substrates. Whereas the first two terms in Eq. (24) describe the surface free energy density per $k_B T_c$, the finite size contribution is contained in the third term in Eq. (24). The alternative method for calculating the force between the substrates by using the stress tensor $T_{\mu\nu}$ (see, c.f., Subsec. II F) yields that the term in square brackets in Eq. (24) corresponds to the force between the substrates.³³ In the following we pursue the stress tensor approach.

F. Force calculation using the stress tensor

This method not only has the advantage that it avoids calculating the difference between two diverging free energies but also that for determining the force at a distance L only the order parameter profile for this distance L is needed. Here we present this method for homogeneous substrates. It is applicable in the same manner for inhomogeneous substrates (see, c.f., Subsec. III A).

The force is a response to the change of the free energy of a system if one of the confining substrates is shifted. A shift of one of the substrates by an infinitesimal vector $\mathbf{a}(\mathbf{r}) = (a_\mu)$, $\mu = 1, \dots, d$, leads to a displacement δr_μ of the components of the vector $\mathbf{r}$, a shift δm of the order parameter, and a change $\delta \mathcal{H}$ in the free energy which is given by an integral over the stress tensor $\mathcal{T}_{\mu\nu}$ and the improvement term $\mathcal{I}_{\mu\nu}$.^{46,47}

$$\delta \mathcal{H} = \int d^d \mathbf{r} \{ \partial_\nu a_\mu [\mathcal{T}_{\mu\nu}(\mathbf{r}) + \mathcal{I}_{\mu\nu}(\mathbf{r})] \}, \quad (25)$$

where the stress tensor $\mathcal{T}_{\mu\nu}$ and the improvement term $\mathcal{I}_{\mu\nu}$ are given in terms of the Lagrange density $\mathcal{L}$, the order parameter m , and their derivatives:

$$\mathcal{T}_{\mu\nu} = \frac{\partial \mathcal{L}}{\partial (\partial_\nu m)} \partial_\mu m - \delta_{\mu\nu} \mathcal{L}, \quad (26)$$

$$\mathcal{I}_{\mu\nu} = -\frac{1}{4} \frac{d-2}{d-1} (\partial_\nu \partial_\mu - \delta_{\mu\nu} \Delta) m^2, \quad (27)$$

where $\delta_{\mu\nu}$ is the Kronecker symbol.

Now we consider a system confined between two homogeneous substrates and described by the Lagrange density in Eq. (19). For this system within mean field theory, i.e., $d = 4$, only the component $\mathcal{T}_{zz}$ of the stress tensor is nonzero:

$$\mathcal{T}_{zz} = \frac{1}{2} (\partial_z m)^2 - \frac{\tau}{2} m^2 - \frac{u}{4!} m^4. \quad (28)$$

If one of the substrates is shifted by α in normal direction (z -direction), $\mathbf{a}(\mathbf{r}) = \alpha \theta(z - z_0) \mathbf{e}_z$, where z_0 is an arbitrary position between the substrates and θ is the Heaviside step function, the Hamiltonian changes by (in the laterally homogeneous case $\mathcal{I}_{\mu\nu} = 0$)

$$\begin{aligned} \delta \mathcal{H} &= \int d^d \mathbf{r} [(\partial_z a_z) \mathcal{T}_{zz}] \\ &= \int d^{d-1} \mathbf{r}_\parallel \int dz (\alpha \delta(z - z_0) \mathcal{T}_{zz}) \\ &= A \alpha \mathcal{T}_{zz}(z = z_0). \end{aligned} \quad (29)$$

Within mean field theory ($d = 4$), A is a three-dimensional surface area. This change $\delta \mathcal{H}$ results in a force $F_{\perp,0}$ in z -direction between the two substrates:

$$\begin{aligned} \frac{F_{\perp,0}}{k_B T_c} &= \frac{\delta \mathcal{H}}{\partial \alpha} \\ &= A \mathcal{T}_{zz}(z = z_0), \end{aligned} \quad (30)$$

where in view of the analysis following below the index 0 indicates that homogeneous substrates with no lateral structure are considered. For $F_{\perp,0} < 0$ (> 0) the confining substrates attract (repel) each other. With Eqs. (28) and (30) the force $f_{\perp,0} = \frac{F_{\perp,0}}{k_B T_c A}$ per area and $k_B T_c$ is given by

$$f_{\perp,0}(t, L) = \frac{1}{2}(\partial_z m(z_0))^2 - \frac{\tau}{2} m(z_0)^2 - \frac{u}{4!} m(z_0)^4. \quad (31)$$

Equation (31) is equivalent to the term in the square brackets in Eq. (24). As expected the force $f_{\perp,0}(L)$ exhibits the scaling property described in Eq. (8) with $\xi^\pm = \xi_0^\pm |t|^{-\nu}$ where $\xi^+ = 1/\sqrt{\tau}$ and $\xi^- = 1/\sqrt{2|\tau|}$. According to Eq. (31) the mean field expressions for $f_{\perp,0}$ and $\tilde{f}_{\perp,0}$ contain a common prefactor $6/u$ which diverges $\sim 1/\epsilon$ for $\epsilon \rightarrow 0$ if one inserts for u its fixed point value $u^* \sim \epsilon$ (compare Eq. (9) where $\alpha \sim \epsilon$). For the quantities studied below we shall consider ratios of such scaling functions for which this prefactor drops out so that these ratios have finite and well defined mean field values in the limit $\epsilon \rightarrow 0$. Therefore the mean field results for these ratios are expected to provide reasonable estimates for their actual counterparts in $d = 3$.

In the case of homogeneous substrates the force between the substrates can be calculated directly based on the stress tensor without calculating the order parameter profile $m(z)$.³³ For the fixed point values $h_1 \rightarrow +\infty$, $h_2 \rightarrow +\infty$, $c_1 = c_2 = 0$ the scaling function $\tilde{f}_{\perp,0}^{++}$ of the force (the index pair ++ denotes that the two surface fields are parallel; the symbol $\pm$ for $T \lesseqgtr T_c$ is suppressed) is given in terms of the complete elliptic integral of the first kind $K(k) = \int_0^{\pi/2} \frac{d\varphi}{\sqrt{1-k^2 \sin^2 \varphi}}$, with the modulus $k \in [0, 1]$:

$$\begin{aligned} \tilde{f}_{\perp,0}^{++}(\tilde{L}^+) &= \frac{6}{(d-1)u} \left\{ (2K(k))^4 k^2 (k^2 - 1) - \theta(-t) \frac{(\tilde{L}^+)^4}{4} \right\}, \\ t > t^* &= - \left(\frac{\pi \xi_0^+}{L} \right)^2, \end{aligned} \quad (32)$$

where $k = k(\tilde{L}^+)$ is determined implicitly via

$$\tilde{L}^+(t > t^*) = \sqrt{|(2K(k))^2 (2k^2 - 1)|}. \quad (33)$$

The term $\frac{(\tilde{L}^+)^4}{4}$ is the bulk contribution to the force below the bulk critical temperature. (If one considers the slit system together with the thin walls to be immersed into the bulk liquid, this bulk contribution to the effective force is absent.) For simplicity and practical advantages below we keep the notation $\tilde{L}^+$ also for temperatures $t < 0$, with the meaning $\tilde{L}^+(t < t^*) = \tilde{L}^- \xi_0^- / \xi_0^+$.

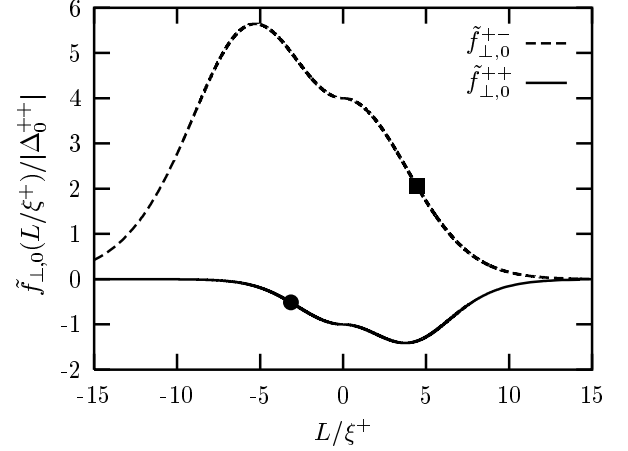


FIG. 1: Universal scaling functions $\tilde{f}_{\perp,0}^{++}(\tilde{L})$ and $\tilde{f}_{\perp,0}^{+-}(\tilde{L})$ of the force within mean field theory (see Eqs. (8) and (31)) between two parallel geometrically flat and chemically homogeneous substrates at distance L for strong parallel (++) and antiparallel (+-) surface fields h_1 and h_2 . For comparison both scaling functions are normalized by the absolute value of $\tilde{f}_{\perp,0}^{++}(0)$ at T_c given by $|\Delta_0^{++}|$ (see Eq. (40)). Note that in order to avoid breaks in the slope for the curves here we have used the same scaling variable $\tilde{L}^+ = L/\xi^+$ both above ($\tilde{L} > 0$) and below ($\tilde{L} < 0$) T_c . ● and ■ correspond to $L/\xi(t = t^*)$ (Eq. (32)) and $L/\xi(t = t^\circ)$ (Eq. (36)), respectively.

For the temperature range $t < t^*$ one has

$$\tilde{f}_{\perp,0}^{++}(\tilde{L}^+) = \frac{6}{(d-1)u} \left\{ (2K(k))^4 k^2 - \theta(-t) \frac{(\tilde{L}^+)^4}{4} \right\}, \quad t < t^*, \quad (34)$$

with

$$\tilde{L}^+(t < t^*) = \sqrt{(2K(k))^2 (k^2 + 1)}. \quad (35)$$

In the case of strong antiparallel surface fields $h_1 \rightarrow +\infty$, $h_2 \rightarrow -\infty$ one has³³

$$\begin{aligned} \tilde{f}_{\perp,0}^{+-}(\tilde{L}^+) &= \frac{6}{(d-1)u} \left\{ (2K(k))^4 (1 - k^2)^2 - \theta(-t) \frac{(\tilde{L}^+)^4}{4} \right\}, \\ t > t^\circ &= 2 \left(\frac{\pi \xi_0^+}{L} \right)^2, \end{aligned} \quad (36)$$

with

$$\tilde{L}^+(t > t^\circ) = \sqrt{2(2K(k))^2 (k^2 + 1)}. \quad (37)$$

For the temperature range $t < t^\circ$ one has

$$\begin{aligned} \tilde{f}_{\perp,0}^{+-}(\tilde{L}^+) &= \frac{6}{(d-1)u} \left\{ (2K(k))^4 - \theta(-t) \frac{(\tilde{L}^+)^4}{4} \right\}, \\ t < t^\circ, \end{aligned} \quad (38)$$

with

$$\tilde{L}^+(t < t^o) = \sqrt{|2(2K(k))^2(2k^2 - 1)|}. \quad (39)$$

Figure 1 shows these scaling functions.

For parallel surface fields the force $\tilde{f}_{\perp,0}^{++}(\text{sign}(t)\tilde{L}^+)$ is always negative, i.e., attractive, and exhibits a minimum at a temperature above T_c . For antiparallel surface fields the force $\tilde{f}_{\perp,0}^{+-}(\text{sign}(t)\tilde{L}^+)$ is positive, i.e., repulsive. For $\tilde{L}^+ \rightarrow \infty$ the forces vanish $\sim e^{-\tilde{L}^+} = e^{-L/\xi^+}$ for $t > 0$ whereas they vanish $\sim e^{-\tilde{L}^+\xi_0^+/\xi_0^-} = e^{-\tilde{L}^-} = e^{-L/\xi^-}$ for $t < 0$.

At the critical point, the forces are proportional to the Casimir amplitudes, which are given by the scaling functions at $\tilde{L} = 0$ (see Eq. (12)):

$$\tilde{f}_{\perp,0}^{++}(\tilde{L} = 0) = \Delta_0^{++}, \quad (40)$$

$$\tilde{f}_{\perp,0}^{+-}(\tilde{L} = 0) = \Delta_0^{+-}. \quad (41)$$

The forces at the critical point are given for $k = 1/\sqrt{2}$ and for $d = 4$ amount to

$$\Delta_0^{++} = -4 \left(K\left(\frac{1}{\sqrt{2}}\right) \right)^4 \frac{6}{(d-1)u} = -15.7561 \frac{6}{u} \quad (42)$$

and

$$\Delta_0^{+-} = 16 \left(K\left(\frac{1}{\sqrt{2}}\right) \right)^4 \frac{6}{(d-1)u} = 63.0242 \frac{6}{u}, \quad (43)$$

i.e., within mean field theory at the critical point the absolute value of the force between homogeneous substrates with antiparallel infinite surface fields is four times larger than for the case with parallel infinite surface fields: $\Delta_0^{+-} = 4|\Delta_0^{++}|$.

III. FORCES BETWEEN INHOMOGENEOUS SUBSTRATES

A. Geometry and general expressions

In this section we consider systems above and at the bulk critical temperature. To simplify the notations in the following we omit the index $+$ indicating quantities above the critical point, e.g., $\tilde{L}^+$ is replaced by $\tilde{L} = L/\xi^+ = L/\xi$.

The substrates investigated here exhibit inhomogeneities in one lateral direction (x direction) and translational invariance in the remaining $d - 2$ directions $y_1, \dots, y_{d-2}$ (extension H). The lateral substrate inhomogeneities form periodic patterns of "positive" stripes ($h_1 = +\infty$) of scaled width $\tilde{S}_+ = S_+/\xi$ and "negative" stripes ($h_1 = -\infty$) of scaled width $\tilde{S}_- = S_-/\xi$ with periodic boundary conditions in x direction (see Fig. 2). (In the preceding paper¹⁶ these quantities are denoted as $\tilde{S}_p$ and $\tilde{S}_n$, respectively.) In the following four different combinations of the substrate structures are investigated:

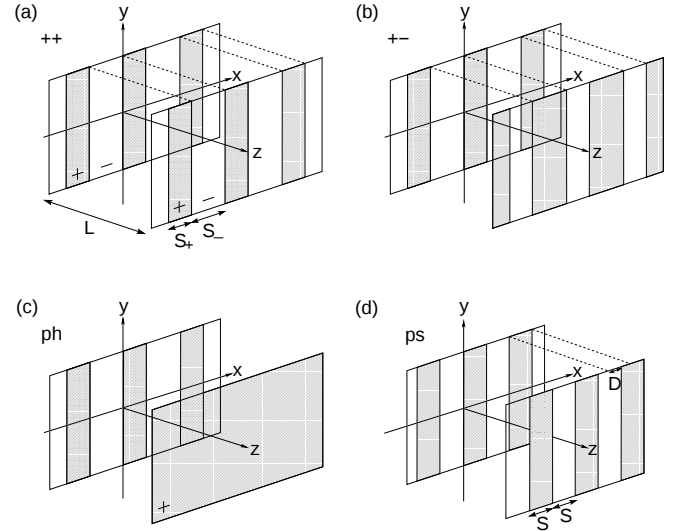


FIG. 2: Two parallel, geometrically flat, and chemically inhomogeneous substrates at distance L . We consider four generic configurations: (a) $++$, (b) $+-$, (c) periodically structured substrate vs. homogeneous substrate, and (d) periodic structures shifted relative to each other. On the white stripes $h_1 = -\infty$, on the grey stripes $h_1 = +\infty$.

1. $++$ configuration: two identically patterned substrates with parallel alignment of the infinite surface fields on the opposing, unshifted stripes.
2. $+-$ configuration: two identically patterned substrates with antiparallel alignment of the infinite surface fields on the opposing, unshifted stripes.
3. *ph* configuration ("periodic-homogeneous" configuration): a patterned substrate opposing a homogeneous substrate.
4. *ps* configuration ("periodic-shifted" configuration): two substrates with the same periodic pattern of stripes of width S but with varying shift D of the stripes.

Various length scales enter describing the inhomogeneities of the substrates, i.e., the set (L, S_+, S_-) in the cases of the $++$ configuration, the $+-$ configuration, and the *ph* configuration. The scaling function $\tilde{f}^{con}(\tilde{L})$ of the force (with $con = (++, +-, ph)$) between the two patterned substrates depends on the scaled distance $\tilde{L}$ and the scaled stripe widths $\tilde{S}_+ = S_+/\xi$ and $\tilde{S}_- = S_-/\xi$ or equivalently on the set $(\tilde{L}, S_+/L, S_-/S_+)$. The latter set exhibits the advantage that upon approaching the critical temperature ($t \rightarrow 0$, $\xi \rightarrow \infty$) only the variable $\tilde{L}$ vanishes. The scaling behavior of the normal force between two inhomogeneous substrates is given by (com-

pare Eq. (8))

$$\begin{aligned} \frac{F_{\perp}^{con}(t, L, S_+, S_-)}{k_B T_c A} &= f_{\perp}^{con}(t, L, S_+, S_-) \\ &= (d-1) L^{-d} \tilde{f}_{\perp}^{con}(\tilde{L}, S_+/L, S_-/S_+). \end{aligned} \quad (44)$$

Without lateral shifts for these configurations $(++, +-, ph)$ the lateral force $F_{\parallel}^{con}$ is zero.

For the ps configuration the parameters entering are the separation L between the substrates, the stripe width S , and the distance D by which the stripes of the second substrate are shifted relatively to the first substrate. The scaling function $\tilde{f}^{ps}(\tilde{L})$ of the force is determined by the set $(\tilde{L}, \tilde{S}/\tilde{L}, \delta)$, with $\delta = \tilde{D}/\tilde{S}$. In this case the scaling behavior of the force normal and lateral to the substrates, respectively, is given by (compare Eq. (8)):

$$\begin{aligned} \frac{F_{\perp}^{ps}(t, L, S, D)}{k_B T_c A} &= f_{\perp}^{ps}(t, L, S, D) \\ &= (d-1) L^{-d} \tilde{f}_{\perp}^{ps}(\tilde{L}, S/L, \delta) \end{aligned} \quad (45)$$

and

$$\begin{aligned} \frac{F_{\parallel}^{ps}(t, L, S, D)}{k_B T_c A} &= f_{\parallel}^{ps}(t, L, S, D) \\ &= (d-1) L^{-d} \tilde{f}_{\parallel}^{ps}(\tilde{L}, S/L, \delta). \end{aligned} \quad (46)$$

For the configurations $++$, $+-$ and ph the order parameter profile exhibits the scaling behavior (with $con = ++, +-, ph$):

$$\begin{aligned} \phi(t, x, z, L, S_+, S_-) \\ = a|t|^{\beta} P^{con} \left(v = \frac{x}{\xi}, w = \frac{z}{\xi}, \tilde{L} = \frac{L}{\xi}, \frac{S_+}{L}, \frac{S_-}{S_+} \right) \end{aligned} \quad (47)$$

where $P^{con}(v, w, \tilde{L}, S_+/L, S_-/S_+)$ is a universal scaling function and a the non-universal amplitude of the bulk order parameter (compare Eq. (12)). In the ps case, the scaling variables S_+/L and S_-/S_+ are again replaced by S/L and δ .

Quantitative results for the scaling functions of the forces follow from the fixed-point Hamiltonian $\mathcal{H}[\phi] = \mathcal{H}_b[\phi] + \mathcal{H}_s[\phi]$ (compare Eqs. (17) and (18)). Here the integration over the surface area $A = N H B$ is $\int d^{d-1} \mathbf{r}_{\parallel} = N \int_0^H d^{d-2} \mathbf{r}_{\parallel} \int_0^B dx$, with $B = 2S$ for the ps configuration and $B = S_+ + S_-$ for the other configurations; N is the number of repeat units in x direction. The mean field approximation $m(x, z)$ of the order parameter profile fulfills the partial differential equation

$$-(\partial_x^2 + \partial_z^2) m + \tau m + \frac{u}{3!} m^3 = 0. \quad (48)$$

The accompanying boundary conditions are given by Eqs. (22) and (23) with h_1 and h_2 varying along x steplike at the chemical steps on the substrate.

From the order parameter profile the force between the substrates can be calculated via the stress tensor method

(see Subsec. IIF). The inhomogeneities in x direction lead to further non-vanishing components of the stress tensor $\mathcal{T}_{\mu\nu}$ and of the improvement term $\mathcal{I}_{\mu\nu}$ (see Eqs. (19), (26) and (27)).

A shift of one substrate by α in the z -direction, $\mathbf{a}(\mathbf{r}) = \alpha\theta(z - z_0)\mathbf{e}_z$, where z_0 is an arbitrary position between the substrates, yields the normal force $f_{\perp}(L)$ per $k_B T_c$ and per area $A = N B H$:

$$\frac{F_{\perp}}{k_B T_c N B H} = f_{\perp}(L) = \frac{1}{B} \int_0^B dx (\mathcal{T}_{zz}(z_0) + \mathcal{J}_{zz}(z_0)), \quad (49)$$

with the components (recall that $\partial_{y_i} m = 0$)

$$\mathcal{T}_{zz} = -\frac{1}{2}(\partial_x m)^2 + \frac{1}{2}(\partial_z m)^2 - \frac{\tau}{2} m^2 - \frac{u}{4!} m^4 \quad (50)$$

and

$$\mathcal{J}_{zz} = \frac{1}{3}(\partial_x m)^2 + \frac{1}{3} m \partial_x^2 m. \quad (51)$$

The lateral force $f_{\parallel}(L)$ per $k_B T_c$ and per area $A = N B H$ follows from considering a shift by β in x -direction, $\mathbf{b}(\mathbf{r}) = \beta\theta(z - z_0)\mathbf{e}_x$:

$$\frac{F_{\parallel}}{k_B T_c N B H} = f_{\parallel}(L) = \frac{1}{B} \int_0^B dx (\mathcal{T}_{xz}(z_0) + \mathcal{J}_{xz}(z_0)), \quad (52)$$

with

$$\mathcal{T}_{xz} = (\partial_x m)(\partial_z m) \quad (53)$$

and

$$\mathcal{J}_{xz} = -\frac{1}{3}(\partial_x m)(\partial_z m) - \frac{1}{3} m \partial_x \partial_z m. \quad (54)$$

Within the present mean field level ($d = 4$) the scaling functions $\tilde{f}_{\perp}(\tilde{L})$ and $\tilde{f}_{\parallel}(\tilde{L})$ as defined in Eqs. (44) - (47) can be expressed in terms of the corresponding scaling functions P of the order parameter:

$$\tilde{f}_{\perp}(\tilde{L}) = \frac{6}{(d-1)u} \frac{\tilde{L}^4}{\tilde{B}} \times \quad (55)$$

$$\begin{aligned} &\int_0^{\tilde{B}} dv \left(-\frac{1}{6}(\partial_v P|_{w_0})^2 + \frac{1}{2}(\partial_w P|_{w_0})^2 \right. \\ &\quad \left. + \frac{1}{3}P(w_0)\partial_v^2 P|_{w_0} - \frac{1}{2}P(w_0)^2 - \frac{1}{4}P(w_0)^4 \right), \end{aligned}$$

$$\begin{aligned} \tilde{f}_{\parallel}(\tilde{L}) &= \frac{6}{(d-1)u} \frac{\tilde{L}^4}{\tilde{B}} \int_0^{\tilde{B}} dv \left(\frac{2}{3}\partial_v P|_{w_0} \partial_w P|_{w_0} \right. \\ &\quad \left. - \frac{1}{3}P(w_0)\partial_v \partial_w P|_{w_0} \right). \end{aligned} \quad (56)$$

Here $\tilde{B} = B/\xi^+$ and $\tilde{L} = L/\xi^+$ denote the scaled extensions of the system in the x and the z direction, respectively.

At the critical point, i.e., for $\tilde{L} = 0$ the scaling function $\tilde{f}_{\perp}$ of the force reduces to a generalized Casimir amplitude Δ which depends on the type of the inhomogeneities of the substrates:

$$\tilde{f}_{\perp}(\tilde{L} = 0) = \Delta^{con} \quad con = ++, +-, ph, ps. \quad (57)$$

B. Forces for the ++ configuration

In this subsection we consider two identical parallel flat substrates with the relative positions of the patterns being in phase (see Fig. 2(a)).

First we want to state some general properties of the force $\tilde{f}_{\perp}^{++}$. The force $\tilde{f}_{\perp}^{++}$ is symmetric w.r.t. to interchanging the width $\tilde{S}_+$ of the positive and the width $\tilde{S}_-$ of the negative stripes:

$$\tilde{f}_{\perp}^{++}(\tilde{L}, q_1, q_2) = \tilde{f}_{\perp}^{++}\left(\tilde{L}, q_1 q_2, \frac{1}{q_2}\right), \quad (58)$$

$$q_1 = \frac{S_+}{L}, \quad q_2 = \frac{S_-}{S_+}.$$

This symmetry equally holds in the case of the $+-$ configuration for the scaling function of the force $\tilde{f}_{\perp}^{+-}$ (see, c.f., Subsec. III C).

If one fixes the width of the positive stripe $\tilde{S}_+$ and considers the limits $\tilde{S}_- \rightarrow 0$ or $\tilde{S}_- \rightarrow \infty$, the force reduces to that between two corresponding homogeneous substrates:

$$\tilde{f}_{\perp}^{++}\left(\tilde{L}, \frac{\tilde{S}_+}{\tilde{L}}, \frac{\tilde{S}_-}{\tilde{S}_+} \rightarrow 0\right) = \tilde{f}_{\perp,0}^{++}(\tilde{L}) \quad (59)$$

$$\tilde{f}_{\perp}^{++}\left(\tilde{L}, \frac{\tilde{S}_+}{\tilde{L}}, \frac{\tilde{S}_-}{\tilde{S}_+} \rightarrow \infty\right) = \tilde{f}_{\perp,0}^{--}(\tilde{L})$$

$$= \tilde{f}_{\perp,0}^{++}(\tilde{L}) \quad (60)$$

This can be seen in Fig. 3.

At the critical temperature T_c , i.e., for $\tilde{L} = 0$, the scaling function of the force depends on S_+/L and S_-/S_+ . In the subsequent limit of large substrate separations (i.e., for $S_+/L \rightarrow 0$) the dependence on S_+/L drops out so that asymptotically the force is governed by a generalized Casimir amplitude $\Delta^{++}(S_-/S_+)$ (see, c.f., Fig. 6).

Figure 3 shows the dependence of the normal force $\tilde{f}_{\perp}^{++}(\tilde{L}, S_+/L, S_-/S_+)$ on the scaled distance $\tilde{L}$ between the substrates for different ratios S_-/S_+ and a fixed ratio S_+/L in comparison with the force $\tilde{f}_{\perp,0}^{++}(\tilde{L})$ (see Fig. 1) for two homogeneous substrates with parallel surface fields. The strength of the attractive force $\tilde{f}_{\perp}^{++}(\tilde{L})$ between patterned substrates is reduced in comparison to the strength of the force $\tilde{f}_{\perp,0}^{++}(\tilde{L})$ between homogeneous substrates. At the critical point, i.e., for $\tilde{L} = 0$, the force $\tilde{f}_{\perp}^{++}(\tilde{L})$ between the substrates takes a finite negative value, i.e., the force between the substrates is attractive. The opposite limit $\tilde{L} \rightarrow \infty$ can be realized either by increasing the distance L between the substrates or by raising the temperature. In both cases the force $\tilde{f}_{\perp}^{++}(\tilde{L})$ between the substrates is expected to vanish exponentially (compare Eq. (10)) which is confirmed by our data. For a given distance $\tilde{L}$ the scaled width $\tilde{S}_+$ of the positive stripe is fixed (due to the choice $S_+/L = 1/2$ in Fig. 3) and therefore for $S_-/S_+ \rightarrow \infty$ the negative stripes become larger and the force between the substrates approaches the force $\tilde{f}_{\perp,0}^{--}(\tilde{L}) = \tilde{f}_{\perp,0}^{++}(\tilde{L})$ between two homogeneous substrates (see Eq. (60)). With increasing stripe

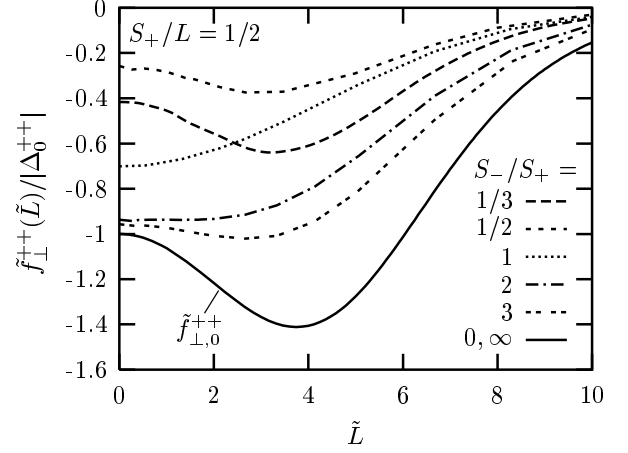


FIG. 3: Scaling function $\tilde{f}_{\perp}^{++}(\tilde{L})$ of the force between two equally patterned substrates, which are in phase, as a function of the scaled distance $\tilde{L} = L/\xi$ between the substrates for different ratios S_-/S_+ of the stripe widths (dashed curves) and for a fixed ratio $S_+/L = 1/2$ compared with the scaling function $\tilde{f}_{\perp,0}^{++}(\tilde{L})$ of the force between two homogeneous substrates (solid curve). The curves are normalized by the absolute value of the Casimir amplitude $|\Delta_0^{++}|$ for the case of homogeneous substrates (see Eq. (40)). The surface fields on opposing stripes are pointing into the same direction.

width the order parameter distributions at the chemical steps forming the stripes become more independent from each other so that the healing of the order parameter profile becomes more pronounced, i.e., the flattening of the cross section at $z = \text{const}$ of the order parameter profile across a chemical step becomes flatter with increasing distance from the substrate.¹⁶ (For narrow stripes this healing is reduced due to the mutual influence of the chemical steps onto each other.) Therefore one can conclude that healing of the order parameter distribution reduces the absolute value of the attractive force. In the limit $S_-/S_+ \rightarrow 0$ the negative stripes disappear and the system again approaches the homogeneous case (see Eq. (59)). Therefore in Fig. 3 the curve for $S_-/S_+ = 1/3$ lies below that one for $S_-/S_+ = 1/2$. For the latter ratio the force is weakened most.

The force $\tilde{f}_{\perp}^{++}(\tilde{L})$ between the substrates also depends on the scaled stripe widths $\tilde{S}_+$ and $\tilde{S}_-$ relative to the plate separation $\tilde{L}$. This is illustrated in Fig. 4 for systems with a fixed ratio S_-/S_+ of the stripe widths but with different ratios S_+/L . It turns out that for fixed distances $\tilde{L} \gtrsim 7$ the magnitude of the force increases for increasing ratios S_+/L because this implies larger stripes. For smaller distances $\tilde{L}$ this trend is again partly inverted due to healing effects such that the magnitude of the force is no longer smallest for the smallest ratio S_+/L .

The influence of the stripe width ratio S_-/S_+ becomes

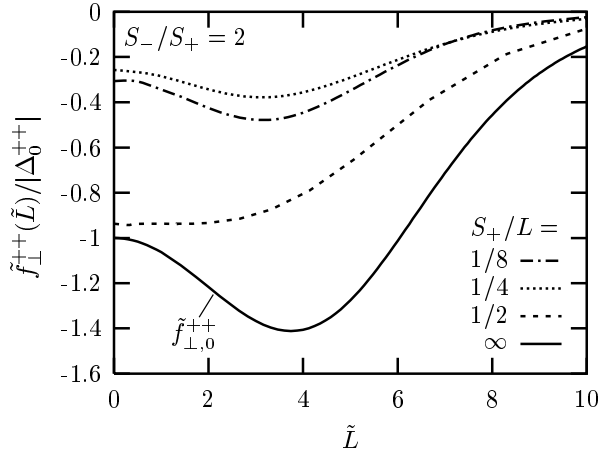


FIG. 4: Scaling function $\tilde{f}_{\perp}^{++}(\tilde{L})$ of the force between two patterned substrates with parallel surface fields normalized by $|\Delta_0^{++}|$ for different ratios S_+/L and a fixed ratio $S_-/S_+ = 2$.

weaker with increasing scaled distance $\tilde{L}$ between the substrates (see Fig. 5). In the limits $S_-/S_+ \rightarrow 0$ and $S_-/S_+ \rightarrow \infty$ the curves reach the values for the force $\tilde{f}_{\perp,0}^{++}(\tilde{L})$ between two homogeneous substrates. For $\tilde{L} = 0$ Fig. 5 renders a universal scaling function $\Delta^{++}(S_-/S_+, S_+/L)$ which in the limit of large L , $S_-/S_+ \rightarrow 0$, and $S_+/L = \text{const}$ or in the limit of large L , $S_-/S_+ \rightarrow \infty$, and $S_+/L = \text{const}$ reduces to the Casimir amplitude Δ_0^{++} for homogeneous systems. In order to obtain the generalized Casimir amplitude $\Delta^{++}(S_-/S_+)$ it is necessary to consider the limit $S_+/L \rightarrow 0$ which is difficult to reach numerically. Approximations thereof are shown in Fig. 6.

This shows how the universal Casimir amplitude can be tuned between its homogeneous value Δ_0^{++} and its maximal value $(\Delta^{++})_{\text{max}} \simeq 0$ via patterning. In the limit $S_+/L \rightarrow 0$ with $S_+/S_- = \text{const}$, i.e., for fixed stripe widths and increasing film thickness, the periodically structured substrates appear as substrates characterized by laterally averaged, effective homogeneous surface fields. For $S_+ = S_-$ the lateral average yields a vanishing effective surface field, mimicking a Dirichlet (ordinary) boundary condition. For Dirichlet-Dirichlet boundary conditions the Casimir force vanishes within mean field theory as used here; fluctuations yield a small attractive force.^{30,31} This reasoning is consistent with the vanishing of $\Delta^{++}(S_-/S_+, S_+/L)$ at $S_+/S_- = 1$ for $S_+/L \rightarrow 0$ (Fig. 6). For $S_+ \neq S_-$ the lateral average yields a non-vanishing effective surface field of equal sign on both substrates, so that, the Casimir amplitude remains negative (i.e., attractive) for $S_+/L \rightarrow 0$ even within mean field theory (Fig. 6).

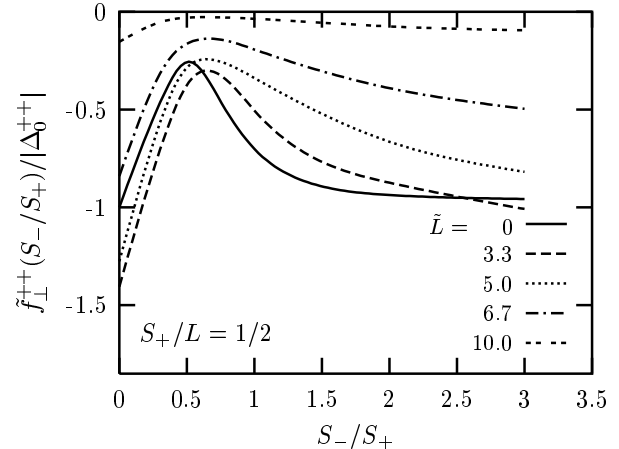


FIG. 5: Scaling function $\tilde{f}_{\perp}^{++}(S_-/S_+)$ of the force between two substrates with their surface field patterns in phase and normalized by $|\Delta_0^{++}|$ as a function of the ratio S_-/S_+ of the stripe widths for various fixed distances $\tilde{L}$ between the substrates and a ratio $S_+/L = 1/2$. The influence of the ratio S_-/S_+ on the force becomes weaker with increasing distance. For $S_-/S_+ = 0, \infty$ one recovers the scaling function for the force between two homogeneous substrates, i.e., for each curve the values at $S_-/S_+ = 0$ and $S_-/S_+ = \infty$ are equal. The solid line represents the system at T_c , i.e., for $\tilde{L} = 0$; in this case for large L with $S_+/L = \text{const}$ and $S_-/S_+ \rightarrow 0$ or $S_-/S_+ \rightarrow \infty$ one recovers the Casimir amplitude Δ_0^{++} for the homogeneous case so that due to the normalization the solid curve reaches -1 .

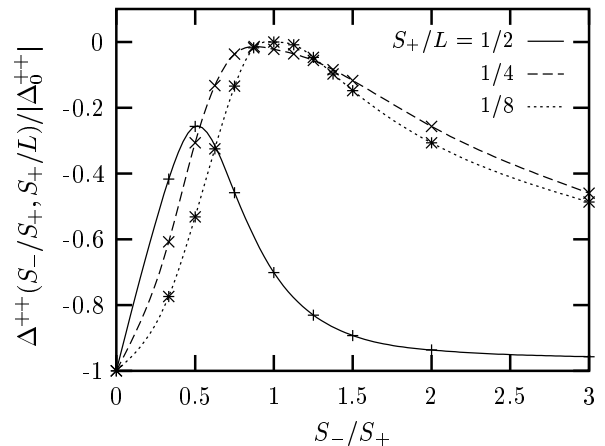


FIG. 6: Generalized Casimir amplitude $\Delta^{++}(S_-/S_+, S_+/L)$ for a critical fluid confined between two substrates with their surface field patterns in phase and normalized by $|\Delta_0^{++}|$ as a function of the stripe width ratio S_-/S_+ for different ratios S_+/L . The curve for $S_+/L = 1/8$ serves as an approximation for the actual generalized Casimir amplitude $\Delta^{++}(S_-/S_+)$ corresponding to the limit $S_+/L \rightarrow 0$. $\Delta^{++}(S_-/S_+)$ varies between $\Delta_0^{++} < 0$ for $S_-/S_+ = 0, \infty$ and its maximum value $(\Delta^{++})_{\text{max}} \simeq 0$ (see main text). Here and in the following figures the curves are smoothly interpolating between the indicated data points.

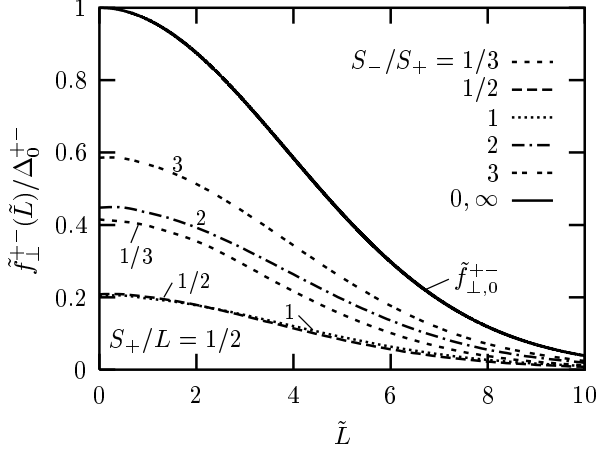


FIG. 7: Scaling function $\tilde{f}_{\perp}^{+-}(\tilde{L})$ of the force between two oppositely patterned substrates (Fig. 2(b)) normalized by Δ_0^{+-} as a function of the scaled distance $\tilde{L} = L/\xi$ between the substrates for different ratios S_-/S_+ of the stripe widths (dashed curves) in comparison with the scaling function $\tilde{f}_{\perp,0}^{+-}(\tilde{L})$ of the force between two homogeneous substrates (solid curve) with a fixed ratio $S_+/L = 1/2$.

C. Forces for the $+-$ configuration

In this subsection we study two parallel substrates with their chemical patterns being the opposite of each other, i.e., a positive stripe of width $\tilde{S}_+$ opposes a negative stripe of the same width (see Fig. 2(b)).

Figure 7 shows how the scaling function $\tilde{f}_{\perp}^{+-}(\tilde{L})$ of the force in units of Δ_0^{+-} depends on the ratio S_-/S_+ of the stripe widths for a fixed ratio S_+/L . As expected this force is repulsive. As in the case of the $++$ configuration the force $\tilde{f}_{\perp}^{+-}(\tilde{L})$ is reduced compared to the force $\tilde{f}_{\perp,0}^{+-}(\tilde{L})$ between two homogeneous substrates, takes a finite value in the limit $\tilde{L} \rightarrow 0$, and vanishes exponentially for $\tilde{L} \rightarrow \infty$. For $S_-/S_+ \rightarrow \infty$ the force tends to the force $\tilde{f}_{\perp,0}^{+-}(\tilde{L})$ between two homogeneous, antagonistic substrates. For small ratios $S_-/S_+ \rightarrow 0$ the negative stripes vanish as the ratio S_+/L is fixed and therefore also in this limit the homogeneous case is reached.

When comparing the forces for systems with the same ratio S_-/S_+ of the stripe widths but with different ratios S_+/L (see Fig. 8) (i.e., systems with different values of scaled widths $\tilde{S}_+$ and $\tilde{S}_-$ of the stripes) the same behavior as for the $++$ configuration is exhibited: for fixed distances $\tilde{L} \gtrsim 7$ and increasing stripe widths the force acting in the system tends monotonically towards the homogeneous regime, for smaller distances $\tilde{L}$ the trend is partly inverted due to competing effects caused by reduced healing for very small stripes.

Figure 9 shows the dependence on the stripe width ratio S_-/S_+ . It becomes weaker with increasing scaled dis-

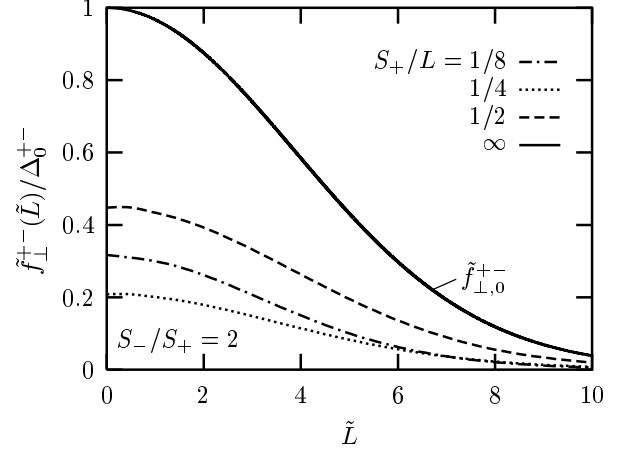


FIG. 8: Scaling function $\tilde{f}_{\perp}^{+-}(\tilde{L})$ of the force between two oppositely patterned substrates (Fig. 2(b)) normalized by Δ_0^{+-} for different ratios S_+/L and a fixed ratio $S_-/S_+ = 2$.

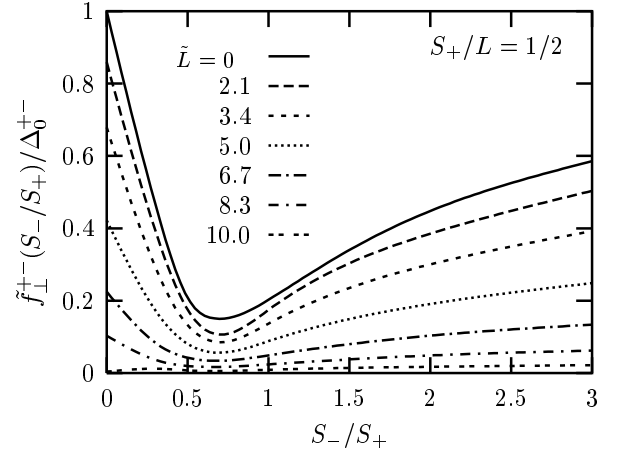


FIG. 9: Scaling function $\tilde{f}_{\perp}^{+-}(S_-/S_+)/\Delta_0^{+-}$ of the force between two oppositely patterned substrates normalized by Δ_0^{+-} as a function of the stripe width ratio S_-/S_+ for various fixed scaled distances $\tilde{L} = L/\xi$ between the substrates and for a ratio $S_+/L = 1/2$. The dependence of the force on the ratio S_-/S_+ becomes weaker with increasing distance.

tance $\tilde{L}$ between the substrates. The limits $S_-/S_+ \rightarrow 0$ and $S_-/S_+ \rightarrow \infty$ correspond to the force $\tilde{f}_{\perp,0}^{+-}(\tilde{L})$ between two homogeneous substrates. For $\tilde{L} = 0$ Fig. 9 leads to a universal scaling function $\Delta^{+-}(S_-/S_+, S_+/L)$ which in the limit of large L , $S_-/S_+ \rightarrow 0$, and $S_+/L = \text{const}$ or in the limit of large L , $S_-/S_+ \rightarrow \infty$, and $S_+/L = \text{const}$ reduces to the Casimir amplitude Δ_0^{+-} for homogeneous antagonistic systems. A generalized Casimir amplitude $\Delta^{+-}(S_-/S_+)$ as the analogue of $\Delta^{++}(S_-/S_+)$ (see Fig. 6) is obtained in the limit $S_+/L \rightarrow 0$. A numerical approximation thereof is shown in Fig. 10. Like for the $++$ configuration (Fig. 6) the actual generalized Casimir amplitude $\Delta^{+-}(S_-/S_+)$ for

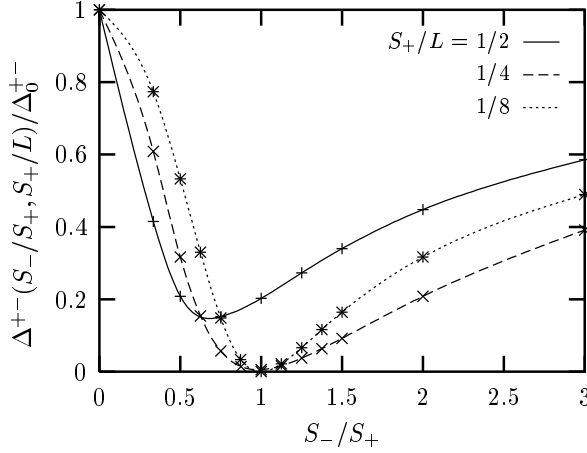


FIG. 10: Generalized Casimir amplitude $\Delta^{+-}(S_{-}/S_{+}, S_{+}/L)$ for a critical fluid confined between two oppositely patterned substrate normalized by Δ_0^{+-} as a function of the stripe width ratio S_{-}/S_{+} for various ratios S_{+}/L . The curve for $S_{+}/L = 1/8$ serves as an approximation for the actual generalized Casimir amplitude $\Delta^{+-}(S_{-}/S_{+})$ corresponding to the limit $S_{+}/L \rightarrow 0$. $\Delta^{+-}(S_{-}/S_{+})$ varies between $\Delta_0^{+-} > 0$ for $S_{-}/S_{+} = 0, \infty$ and its minimum value $(\Delta^{+-})_{min} \simeq 0$ (see main text).

the $+-$ configuration vanishes for a stripe width ratio $S_{+}/S_{-} = 1$ in the limit $S_{+}/L \rightarrow 0$ corresponding effectively to Dirichlet boundary conditions evoking a vanishing force within mean field theory (Fig. 10).

D. Forces for the ph configuration

The configuration of a patterned substrate at $z = 0$ parallel to a homogeneous substrate with a positive surface field $h_1 = +\infty$ positioned at $z = L$ is of special interest because it can be realized by a binary liquid mixture with its bulk in the vapor phase forming a wetting film near demixing on a patterned substrate at $z = 0$ with film thickness L such that at the free liquid-vapor interface the vapor plays the role of the homogeneous substrate. This kind of experiment is a natural extension of the critical Casimir experiments as carried out in Ref. 48 on a homogeneous substrate.

Figure 11 illustrates the dependence of the scaling function $\tilde{f}_{\perp}^{ph}(\tilde{L})$ of the force between a patterned and a homogeneous substrate on the stripe widths ratio S_{-}/S_{+} for a fixed ratio S_{+}/L . For increasing negative stripe widths and fixed separations of the plates (i.e., $S_{-}/S_{+} \rightarrow \infty$) the force becomes more repulsive and reaches the limiting case of a system with two homogeneous substrates with antiparallel surface fields. In contrast, for vanishing negative stripes (i.e., $S_{-}/S_{+} \rightarrow 0$) the force is attractive and converges to the force between two homogeneous substrates with parallel surface fields.

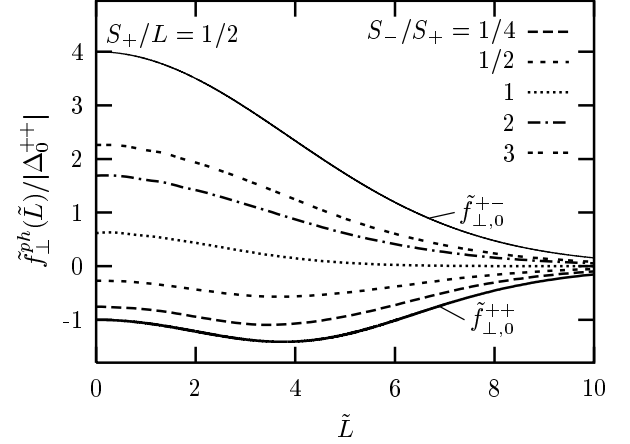


FIG. 11: Scaling function $\tilde{f}_{\perp}^{ph}(\tilde{L})$ of the force between a patterned and a homogeneous substrate with a positive surface field normalized by $|\Delta_0^{++}|$ as a function of the scaled distance between the substrates for different stripe width ratios S_{-}/S_{+} and a fixed ratio $S_{+}/L = 1/2$.

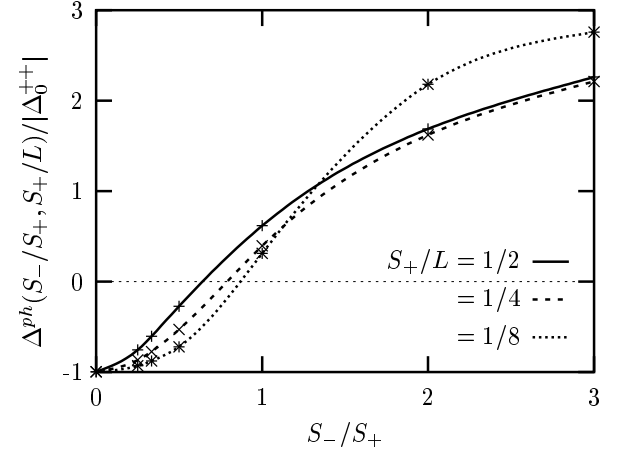


FIG. 12: Generalized Casimir amplitude $\Delta^{ph}(S_{-}/S_{+}, S_{+}/L)$ for a critical fluid confined between a patterned and a homogeneous substrate normalized by $|\Delta_0^{++}|$ as a function of the stripe width ratio S_{-}/S_{+} for various ratios S_{+}/L . As in Fig. 6 and 10 the curve for $S_{+}/L = 1/8$ serves as an approximation for the actual generalized Casimir amplitude $\Delta^{ph}(S_{-}/S_{+})$ corresponding to the limit $S_{+}/L \rightarrow 0$. $\Delta^{ph}(S_{-}/S_{+})$ varies between $\Delta_0^{++} < 0$ for $S_{-}/S_{+} = 0$ and $\Delta_0^{+-} > 0$ for $S_{-}/S_{+} = \infty$. Consequently Δ^{ph} has a zero and we find $\Delta^{ph}(S_{-}/S_{+}) = 0$ for $S_{-} \simeq S_{+}$.

At the critical point, i.e., for $\tilde{L} = 0$, and for large L with $S_{+}/L = \text{const}$ the scaling function $\tilde{f}_{\perp}^{ph}$ reduces to a universal function $\Delta^{ph}(S_{-}/S_{+}, S_{+}/L)$ (see Fig. 12) which interpolates between Δ_0^{++} at $S_{-}/S_{+} = 0$ and Δ_0^{+-} at $S_{-}/S_{+} = \infty$ and therefore has a zero. For $S_{+}/L \rightarrow 0$, according to Fig. 12 $\Delta^{ph}(S_{-}/S_{+})$ vanishes for $S_{-}/S_{+} \simeq 1$. For this stripe width ratio, at the critical point the Casimir force decays faster than L^{-d} .

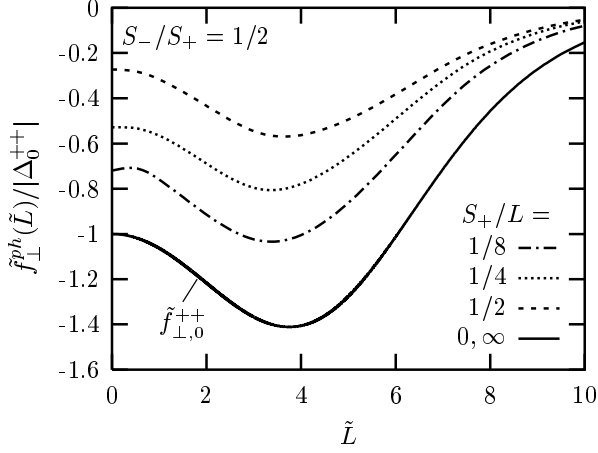


FIG. 13: Scaling function $\tilde{f}_{\perp}^{ph}(\tilde{L})$ of the force between a patterned and a homogeneous substrate with $h_1 = +\infty$ normalized by $|\Delta_0^{++}|$ for different ratios S_+/L with $S_-/S_+ = 1/2$ fixed.

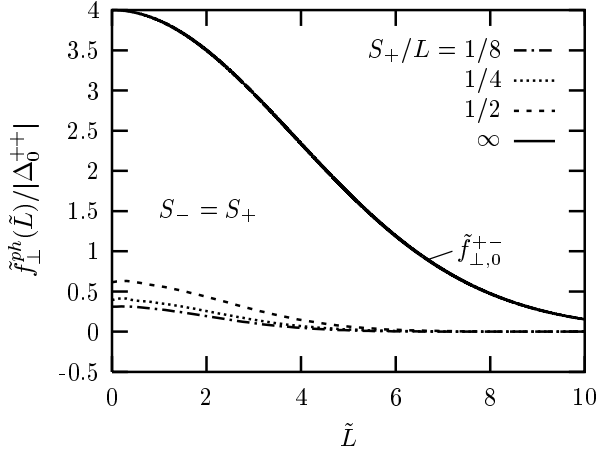


FIG. 14: Scaling function $\tilde{f}_{\perp}^{ph}(\tilde{L})$ of the force between a patterned and a homogeneous substrate with $h_1 = +\infty$ normalized by $|\Delta_0^{++}|$ for different ratios S_+/L with $S_- = S_+$ fixed.

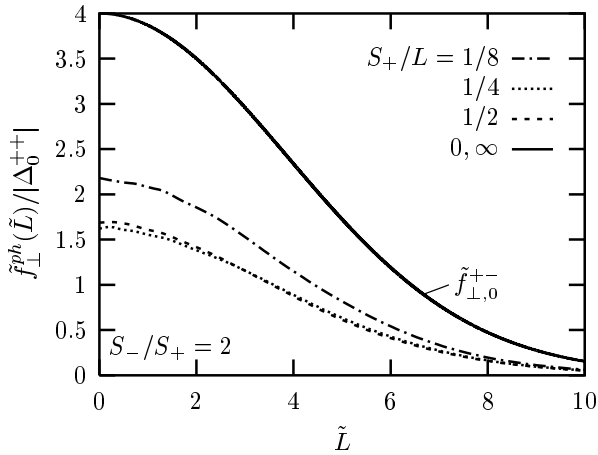


FIG. 15: Scaling function $\tilde{f}_{\perp}^{ph}(\tilde{L})$ of the force between a patterned and a homogeneous substrate with $h_1 = +\infty$ normalized by $|\Delta_0^{++}|$ for different ratios S_+/L with $S_-/S_+ = 2$ fixed.

The dependence of the force on the scaled distance between the substrates is shown in Figs. 13, 14, and 15 for three different ratios S_+/L and three different ratios S_-/S_+ . For simultaneously decreasing positive and negative stripe widths $\tilde{S}_+ \rightarrow 0$ and $\tilde{S}_- \rightarrow 0$ the force tends - depending on the ratio S_-/S_+ - towards those for the different homogeneous cases, i.e., for $S_-/S_+ > 1$ towards the force between plates with antiparallel surface fields and for $S_-/S_+ < 1$ towards the force between plates with parallel surface fields. The larger the ratio S_+/L , the larger is the scaled stripe width $\tilde{S}_+$ for $\tilde{L}$ fixed and the more developed is the healing of the order parameter distribution across the chemical steps. Therefore the absolute value of the force is reduced as compared to smaller stripe widths.

E. Comparison of the configurations

In this subsection we compare the forces for the aforementioned configurations $++$, $+-$ and ph . First, we find that the forces for the $++$ configuration and the $+-$ configuration are of the same order of magnitude. For the same stripe geometries the absolute value of the force scaling function $\tilde{f}_{\perp}^{+-}(\tilde{L})$ for the $+-$ configuration is always larger than the absolute value of the force scaling function $\tilde{f}_{\perp}^{++}(\tilde{L})$ for the $++$ configuration (see Fig. 16). The ratio $|\Delta^{+-}(S_-/S_+, S_+/L)|/|\Delta^{++}(S_-/S_+, S_+/L)|$ of the generalized Casimir amplitudes for the $++$ configuration and the $+-$ configuration is smaller than the factor 4 found for the forces between homogeneous substrates (for details see Fig. 17). This is caused by the healing effect for the order parameter distribution.

For a ratio $S_+/L = 1/2$ (see Fig. 16(a)) and a ratio $S_-/S_+ < 1$ the force $\tilde{f}_{\perp}^{ph}(\tilde{L})$ between the substrates for the ph configuration is larger than the force $\tilde{f}_{\perp}^{++}(\tilde{L})$ for the $++$ configuration but smaller than the force $\tilde{f}_{\perp}^{+-}(\tilde{L})$ for the $+-$ configuration. If the stripes become smaller (i.e., $S_+/L \rightarrow 0$) (see Fig. 16(b)) the force between the substrates for the ph configuration becomes larger than for the $++$ and the $+-$ configuration.

For the ratio $S_-/S_+ = 1$ these effects are even more pronounced due to the antisymmetry of the order parameter profiles: Fig. 16(c) shows the scaling function in the case $S_+/L = 1/2$ for which the force between the substrates for the ph configuration is even smaller than both the force for the $++$ and the force for the $+-$ configuration. With decreasing stripe widths (see Fig. 16(d)) the force between the substrates for the ph configuration is significantly larger than for the $++$ and the $+-$ configuration. For these very small stripes and for $S_-/S_+ = 1$ the structured substrate effectively appears as a surface with a surface field tending to zero which is effectively equivalent to the Dirichlet boundary condition. In contrast the homogeneous substrate in the ph configuration still has a positive surface field such that for the ph configuration a force remains even in the limit $S_+/L \rightarrow 0$.

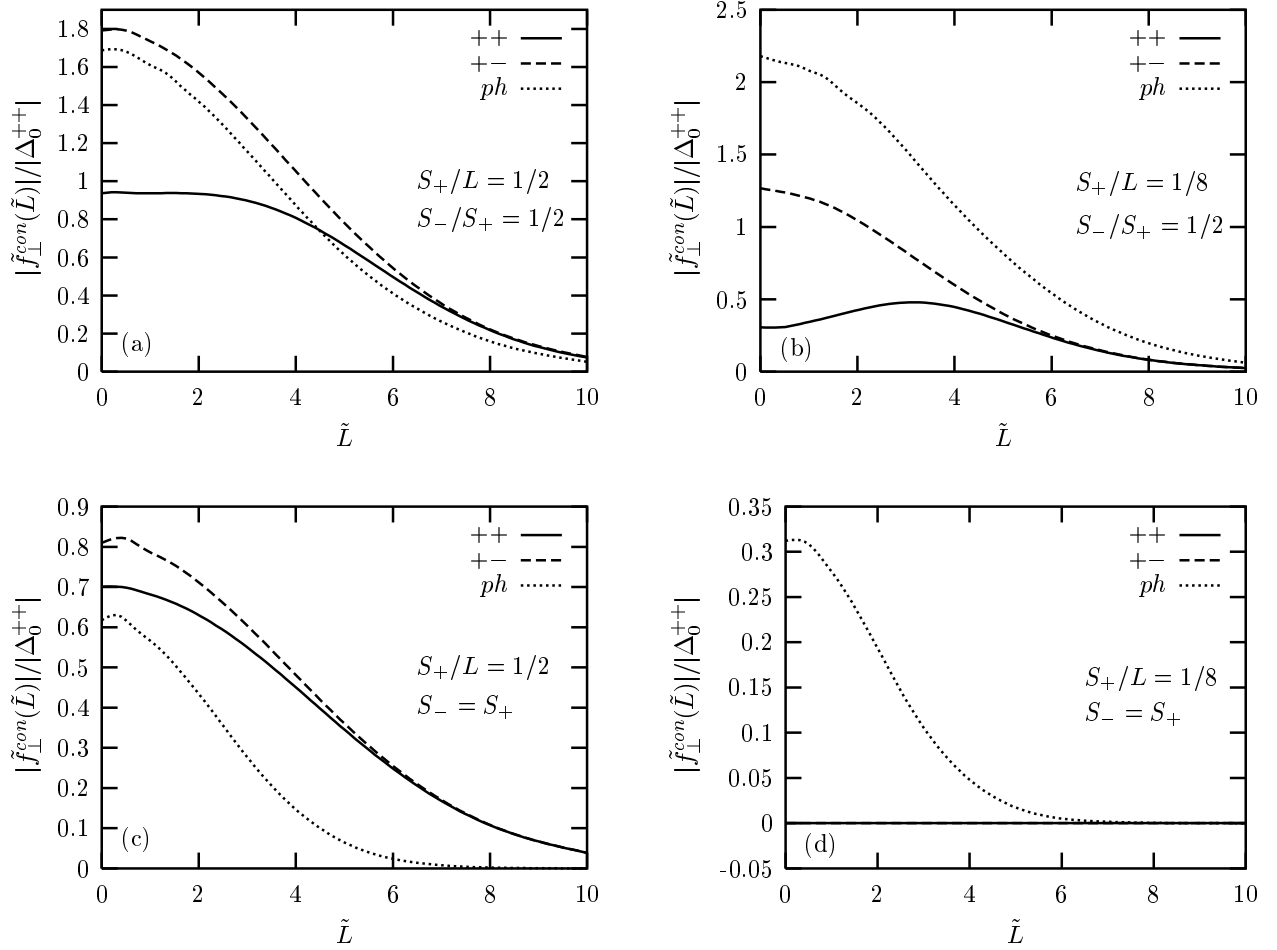


FIG. 16: Comparison of the absolute values of the scaling functions $\tilde{f}_\perp^{\text{con}}(\tilde{L})$ for the forces between patterned substrates (where $\text{con} = ++, +-, ph$) normalized by $|\Delta_0^{++}|$, (a) for the ratios $S_+/L = 1/2$ and $S_-/S_+ = 2$, (b) $S_+/L = 1/8$ and $S_-/S_+ = 2$, (c) $S_+/L = 1/2$ and $\tilde{S}_- = \tilde{S}_+$, and (d) $S_+/L = 1/8$ and $\tilde{S}_- = \tilde{S}_+$; on this scale the values for both the $++$ and the $+-$ configuration cannot be distinguished from zero.

The Casimir amplitude Δ^{o+} of the force between a substrate with ordinary (Dirichlet) boundary condition and a substrate with $+$ boundary condition within mean field theory is given by³³

$$\Delta^{o+} = -\frac{1}{4}\Delta_0^{++}. \quad (61)$$

The value $\tilde{f}_\perp^{ph}(0)/|\Delta_0^{++}|$ for $S_+/L = 1/8$ in Fig. 16(d) is still above this value because the limit $S_+/L \rightarrow 0$ is not yet reached.

Figure 17 shows the dependence of the ratio $\Delta^{+-}(S_-/S_+, S_+/L)/|\Delta^{++}(S_-/S_+, S_+/L)|$ of the generalized Casimir amplitudes for the $+-$ configuration and the $++$ configuration on the stripe width ratio S_-/S_+ . For $S_-/S_+ = 0, \infty$ the substrates are homogeneous and therefore in these limits $\Delta^{+-}(S_-/S_+, S_+/L)/|\Delta^{++}(S_-/S_+, S_+/L)| = \Delta_0^{+-}/|\Delta_0^{++}| = 4$. (Since both Δ^{++} and Δ^{+-} are very

small for $S_-/S_+ \simeq 1$ (see Figs. 6 and 10), the numerical estimates for this ratio become unreliable there.)

F. Lateral shift

Finally we consider two parallel substrates endowed with the same pattern but laterally shifted relative to each other by a distance D in x direction, $\tilde{D} = D/\xi$ (see Fig. 2(d)). In order to limit the number of relevant length scales here we choose $S_+ = S_- \equiv S$ and $\tilde{S}_+ = \tilde{S}_- \equiv \tilde{S}$, respectively, so that with the relative shift $\delta \equiv D/S = \tilde{D}/\tilde{S}$ the set of variables is $(\tilde{L}, \tilde{S}, \tilde{D})$ or $(\tilde{L}, \tilde{S}, \delta)$. This set of variables is chosen to simplify the presentation of the scaling functions of the force but it has the disadvantage that upon approaching the critical point both the scaled distance $\tilde{L}$ and the scaled stripe width $\tilde{S}$ vanish which makes it difficult to calculate the

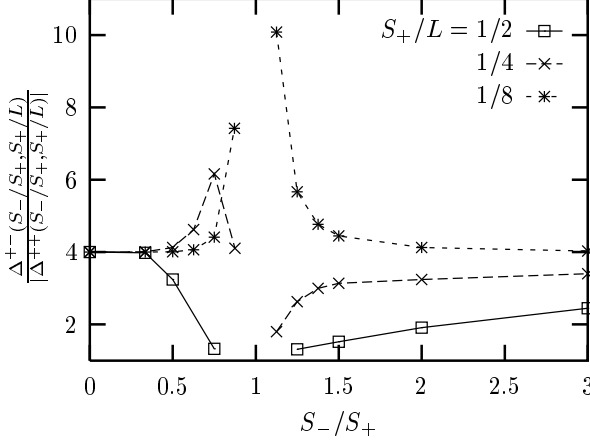


FIG. 17: Ratio $\Delta^{+-}(S_-/S_+, S_+/L)/|\Delta^{++}(S_-/S_+, S_+/L)|$ of the generalized Casimir amplitudes for the $+-$ configuration and the $++$ configuration as a function of the ratio S_-/S_+ of the stripe widths. The limits $S_-/S_+ = 0, \infty$ correspond to homogeneous substrates for which the ratio equals $\Delta_0^{+-}/|\Delta_0^{++}| = 4$ (see Subsec. IIF). It is difficult to evaluate numerically this ratio for $S_-/S_+ \simeq 1$ because there both $\Delta^{+-}(S_-/S_+, S_+/L)$ and $\Delta^{++}(S_-/S_+, S_+/L)$ are very small.

forces between the substrates at the critical point. In order to obtain the forces at T_c the set of variables $(\tilde{L}, \tilde{S}/\tilde{L}, \tilde{D}/\tilde{S}) = (\tilde{L}, S/L, \delta)$ in which only the scaled distance $\tilde{L}$ vanishes in the limit $T \rightarrow T_c$ is chosen. For this configuration we study the force $\tilde{f}_\perp^{ps}(\tilde{L}, \tilde{S}, \delta)$ normal to the substrate like for the previous configurations. But in this case in addition a lateral force $\tilde{f}_\parallel^{ps}(\tilde{L}, \tilde{S}, \delta)$ parallel to the substrates emerges.

1. Normal force

Figure 18 illustrates the influence of the relative shift on the normal force $\tilde{f}_\perp^{ps}(\tilde{L}, \tilde{S}, \delta)$. For a vanishing shift $\delta = 0$ the system is in the patterned $++$ configuration and the force is attractive for all scaled distances $\tilde{L}$ between the substrates. With increasing shift δ (i.e., $D \rightarrow S$) the force increases and becomes repulsive for all scaled distances $\tilde{L}$ until the corresponding patterned $+-$ configuration is reached for $\delta = 1$. For $\delta \gtrsim 0.4$ the force becomes repulsive for all $\tilde{L}$.

The influence of the scaled stripe width $\tilde{S}$ on the scaling function $\tilde{f}_\perp^{ps}(\tilde{L}, \tilde{S}, \delta)$ is shown in Fig. 19 through the dependence of $\tilde{f}_\perp^{ps}$ on the ratio L/S . The curves for the scaled stripe widths $\tilde{S} = 1.0$, $\tilde{S} = 2.0$, and $\tilde{S} = 3.0$ with the same relative shift $\delta = 0.2$ do not coincide. This demonstrates that the force $\tilde{f}_\perp^{ps}(\tilde{L}, \tilde{S}, \delta)$ does not reduce to an effective scaling function of only the two variables L/S and δ .

In Fig. 20 the data contained in Fig. 18 are shown as to

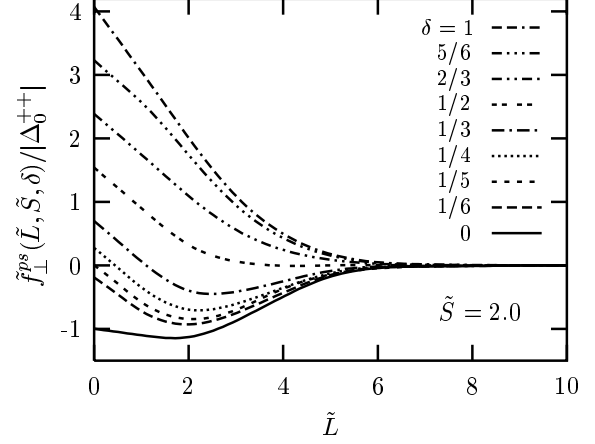


FIG. 18: Scaling function $\tilde{f}_\perp^{ps}(\tilde{L}, \tilde{S}, \delta)$ of the normal force between two substrates patterned identically with positive and negative stripes of widths $S_+ = S_- = S$ and $\tilde{S} = 2.0$ for various lateral shifts $\delta = D/S = \tilde{D}/\tilde{S}$. The scaling function of the force is normalized by $|\Delta_0^{++}|$. The values for $\tilde{L} = 0$ are obtained by taking the values for small $\tilde{L}$ and extrapolating them linearly to $\tilde{L} = 0$.

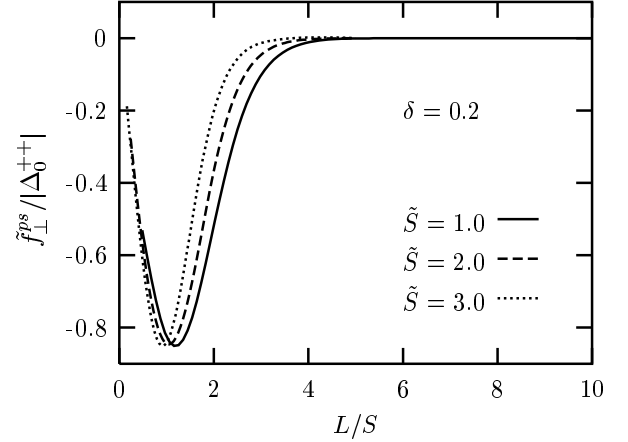


FIG. 19: Scaling function $\tilde{f}_\perp^{ps}$ of the normal force between two substrates patterned with positive and negative stripes of equal width $\tilde{S} = 1.0$ (solid line), $\tilde{S} = 2.0$ (dashed line), and $\tilde{S} = 3.0$ (dotted line) as function of L/S and with a relative shift of $\delta = 0.2$. Here $\tilde{f}_\perp^{ps}$ is considered as a scaling function of the scaling variables L/S , $\tilde{S}$, and δ . The scaling function of the force is normalized by $|\Delta_0^{++}|$.

visualize the dependence on the relative shift $\delta = D/S$. For small scaled distances $\tilde{L}$ the force scaling function $\tilde{f}_\perp^{ps}$ depends strongly on the relative shift, with the curves interpolating between the value of the force scaling function $\tilde{f}_\perp^{++}(\tilde{L})$ for the patterned $++$ configuration ($\delta = 0$) and of the force scaling function $\tilde{f}_\perp^{+-}(\tilde{L})$ for the patterned $+-$ configuration ($\delta = 1$). The dependence on δ disappears with increasing scaled distance $\tilde{L} \rightarrow \infty$ between

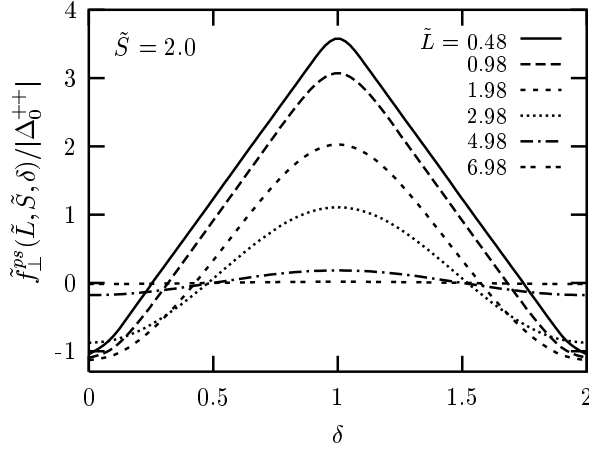


FIG. 20: Same data as in Fig. 18 shown as function of the relative shift $\delta = D/S$.

the substrates.

The normal force at the critical point is characterized by a generalized Casimir amplitude $\Delta^{ps}(\delta, S/L)$ shown in Fig. 21 for the ratios $S/L = 1/2, 1/4, 1/8$. The generalized Casimir amplitude $\Delta^{ps}(\delta, S/L)$ varies as a function of the relative shift δ between $\Delta^{++}(S_-/S_+ = 1, S_+/L)$ for $\delta = 0$ and $\Delta^{+-}(S_-/S_+ = 1, S_+/L)$ for $\delta = 1$. Like the generalized Casimir amplitudes $\Delta^{++}(S_-/S_+, S_+/L)$ and $\Delta^{+-}(S_-/S_+, S_+/L)$ vanishing for a stripe width ratio $S_-/S_+ = 1$ (Figs. 6 and 10) in the limit $S_+/L \rightarrow 0$ – resembling effective Dirichlet boundary conditions –, the generalized Casimir amplitude $\Delta^{ps}(\delta, S/L)$ vanishes, within mean field theory, in the limit $S/L \rightarrow 0$, too, for all values of the shift δ (recall that here $S_+ = S_- \equiv S$).

2. Lateral force

The scaling function $\tilde{f}_{\parallel}^{ps}(\tilde{L}, \tilde{S}, \delta)$ of the lateral forces is calculated according to Eqs. (52) and (56). Figure 22 shows the dependence of the scaling function $\tilde{f}_{\parallel}^{ps}(\tilde{L}, \tilde{S}, \delta)$ for the lateral force on the scaled distance $\tilde{L}$ between the substrates for a fixed scaled stripe width $\tilde{S} = 2.0$. For the relative shifts $\delta = 0, 2$ and $\delta = 1$, which correspond to the patterned $++$ and the patterned $+-$ configuration, respectively, the lateral force $\tilde{f}_{\parallel}^{ps}(\tilde{L}, \tilde{S}, \delta)$ vanishes identically. With increasing shifts up to $\delta \approx 0.5$ the force first becomes increasingly restoring and for shifts $\delta \gtrsim 0.5$ it decreases again towards 0. For shifts $0 < \delta < 1$ the direction of the force is opposed to the direction of the shift, whereas for shifts $1 < \delta < 2$ the force acts into the direction of the shift.

At the critical point, i.e., for $\tilde{L} = 0$ and $S \rightarrow \infty$ in order to keep $\tilde{S} = 2$ as in Fig. 22 the patterning becomes irrelevant such that the lateral force attains 0. With increasing distance $\tilde{L}$ the force reaches a minimum (maximum) for

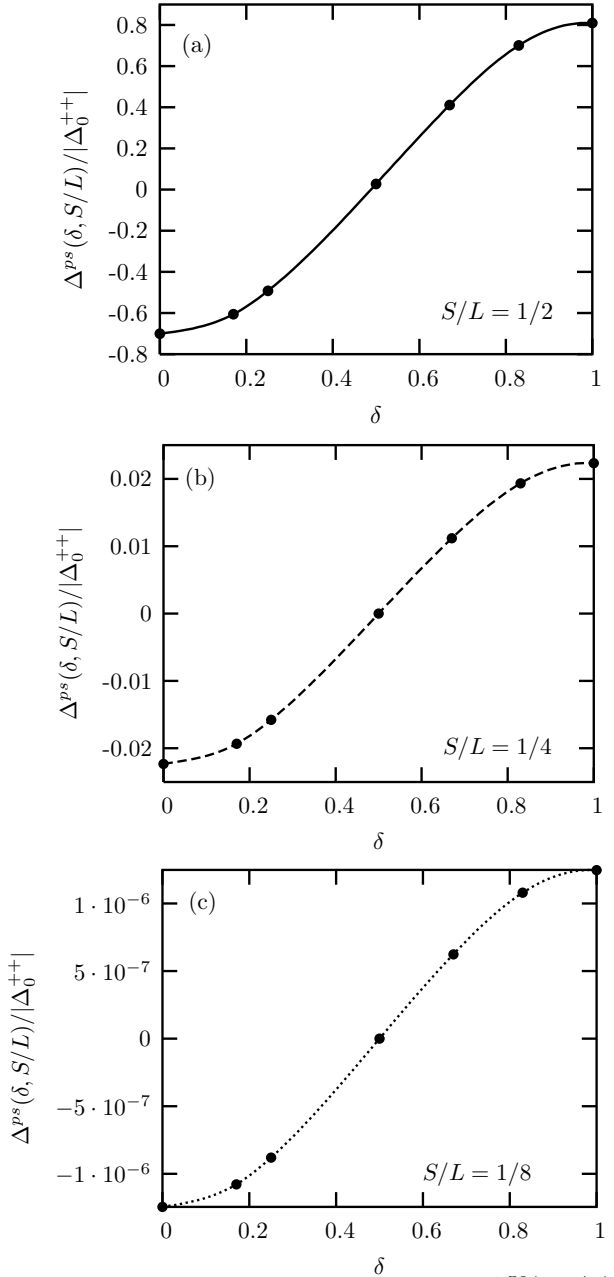


FIG. 21: Generalized Casimir amplitude $\Delta^{ps}(\delta, S/L)$ for a critical fluid confined between two identically structured substrates with relative shift δ normalized by $|\Delta_0^{++}|$ as a function of the relative shift δ (a) for a ratio $S/L = 1/2$, (b) for a ratio $S/L = 1/4$, (c) for a ratio $S/L = 1/8$; $S_+ = S_- \equiv S$.

$0 < \delta < 1$ ($1 < \delta < 2$) at a certain $\tilde{L}(\delta) > 0$ and in the limit $\tilde{L} \rightarrow \infty$ the force vanishes exponentially due to the same arguments which apply to the normal forces. Thus as a function of $\tilde{L}$ the lateral force reflects the behavior of the normal force shown in Fig. 18.

The dependence of the scaling function of the lateral force $\tilde{f}_{\parallel}^{ps}(\tilde{L}, \tilde{S}, \delta)$ on the relative shift δ is illustrated directly in Fig. 23 for various fixed scaled distances $\tilde{L}$ between the substrates and for $\tilde{S} = 2$. The force

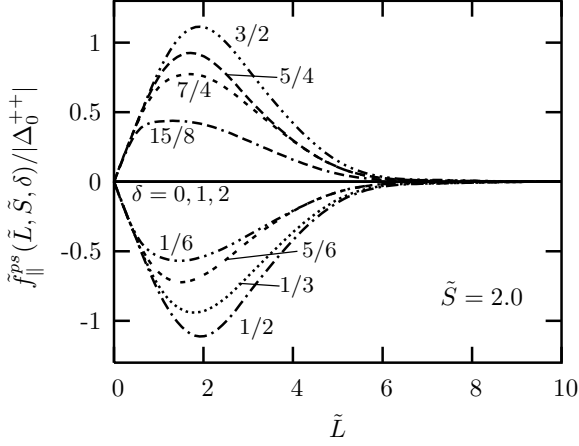


FIG. 22: Scaling function $\tilde{f}_{\parallel}^{ps}(\tilde{L}, \tilde{S}, \delta)$ of the lateral force, normalized by $|\Delta_0^{++}|$, between two identically patterned substrates as function of the distance $\tilde{L}$ between the substrates for various relative shifts δ and for a scaled stripe width $\tilde{S} = 2.0$.

attains a minimum for $\delta \approx 0.5$, i.e., for this value the restoring force is strongest. For $\delta \approx 1.5$ the repulsive force attains a maximum. For $\tilde{L} \ll \tilde{S}$ the force scaling function exhibit plateaus as function of δ around $\delta = 0.5$ and $\delta = 1.5$. At $\delta = 1$ the force scaling function has an inflection point which corresponds to an unstable configuration.

The singular free energy cost for shifting the two substrates relative to each other is given by (see Eq. (47))

$$U_{\parallel}^{ps}(D, L, S, t) = k_B T_c \frac{2NS^2H}{L^d} (d-1) \tilde{U}_{\parallel}^{ps}(\delta, \tilde{L}, \tilde{S}), \quad (62)$$

where N is the number of repeat units of width $2S$ and H is the extension of the system in the translational invariant direction so that $A = 2NSH$. The dimensionless scaling function

$$\tilde{U}_{\parallel}^{ps}(\delta, \tilde{L}, \tilde{S}) = - \int_0^{\delta} d\delta' \tilde{f}_{\parallel}^{ps}(\delta', \tilde{L}, \tilde{S}), \quad (63)$$

is shown in Fig. 24.

For given lateral features N , S , and H one has $2NS^2H/L^d \ll 1$ for L sufficiently large so that $U_{\parallel}^{ps} \ll k_B T_c$ which implies that the structured substrates can float against each other via thermal activation if they are not externally fixed. For $N = 50$ repeat units consisting of a positive and a negative stripe each of width $S = 100$ nm and for an extension $H = 10 \mu\text{m}$ the above condition is met for $L \gg 2 \mu\text{m}$.

The scaling function $\tilde{U}_{\parallel}^{ps}(\delta, \tilde{L}, \tilde{S})$ of the free energy exhibits a maximum $\tilde{U}_{max}$ for $\delta = 1$, i.e., $D = S$. This maximum is the activation barrier which one has to over-

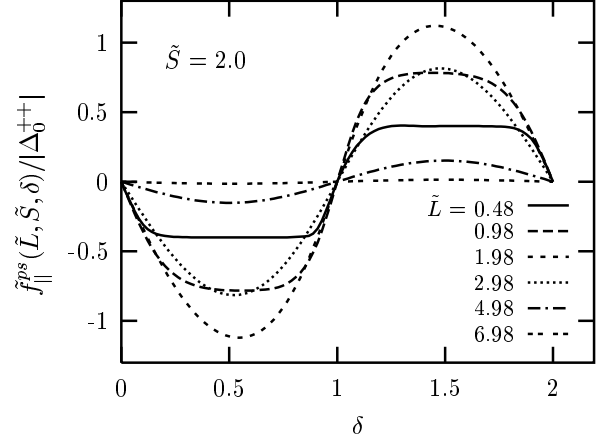


FIG. 23: Scaling function $\tilde{f}_{\parallel}^{ps}(\tilde{L}, \tilde{S}, \delta)$ of the lateral force normalized by $|\Delta_0^{++}|$ between two identically patterned substrates as a function of the relative shift δ for different scaled distances $\tilde{L}$ between the substrates and for a scaled stripe width $\tilde{S} = 2.0$.

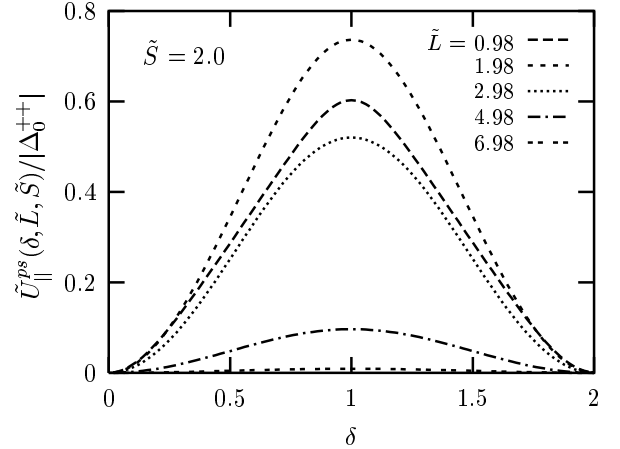


FIG. 24: The scaling function $\tilde{U}(\delta, \tilde{L}, \tilde{S})$, normalized by $|\Delta_0^{++}|$, of the singular contribution to the cost of free energy to shear the patterned substrates relative to each other by the relative shift $\delta = D/S$. The scaling function has its maximum at $\delta = 1$, minima are at $\delta = 0$ and $\delta = 2$, and turning points at $\delta = 0.5$ and $\delta = 1.5$.

come to shear the patterned system from the $++$ configuration at $\delta = 0$ over the $+-$ configuration at $\delta = 1$ to the $++$ configuration at $\delta = 2$. Here the absolute values of the free energy do not matter. The turning points at $\delta = 0.5$ and $\delta = 1.5$ of the scaling function of the free energy correspond to the maximal lateral force between the substrates.

Figure 25 shows the universal activation barrier $\tilde{U}_{max}(\tilde{L}, \tilde{S})$ with its dependence on the scaled distance $\tilde{L}$ between the substrates for a fixed scaled stripe width $\tilde{S} = 2$. This scaling function vanishes for $\tilde{L} \rightarrow 0$ and

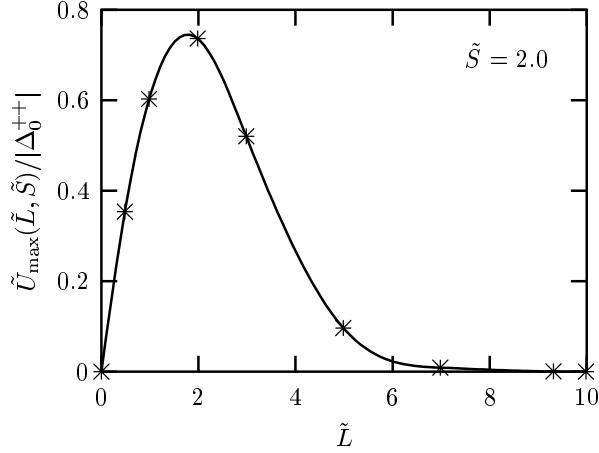


FIG. 25: Scaling function $\tilde{U}_{max}(\tilde{L}, \tilde{S})$, normalized by $|\Delta_0^{++}|$, of the activation barrier as a function of the scaled distance $\tilde{L}$ for a fixed scaled stripe width $\tilde{S} = 2.0$.

$\tilde{L} \rightarrow \infty$ and, for this choice of $\tilde{S}$, exhibits a maximum for $\tilde{L} \approx 2$.

3. Comparison with lateral van der Waals forces

As described in the Introduction the chemical patterning requires at least one monolayer of the substrate to be composed of alternating stripes of distinct chemical species which provide the contrast in preference for the two types of particles forming the binary liquid mixture exposed to this lateral structure. Since these two substrate species interact not only with the fluid particles but also among each other, their inhomogeneous lateral distribution gives rise to a lateral force even in the absence of the fluid between the two confining substrates. This lateral force stems from the direct van der Waals or dispersion forces between the substrate particles and provides a nonsingular background contribution which adds to the singular lateral force discussed above. This nonsingular contribution can be determined separately by taking the fluid out of the system.

In order to estimate the background force we consider two types of particles $i, j = +, -$ interacting pairwise via Lennard-Jones potentials which are characterized by energy and length parameters ϵ_{ij} and σ_{ij} , respectively. Their actual number density on the stripes are η_i . Since $L \gg \sigma_{ij}$, only the attractive part of the Lennard-Jones potentials matters. As discussed in Appendix A (see Eq. (A18)), the lateral van der Waals force (for $d = 3$) has the form

$$\frac{F_{\parallel}^{vdW}}{2NSH}(D, S, L) = \frac{E}{S^5} \tilde{f}_{\parallel}^{vdW}\left(\frac{L}{S}, \delta\right), \quad (64)$$

where $E = E_{++} - 2E_{+-} + E_{--}$ and $E_{i,j} = 4\epsilon_{ij}\sigma_{ij}^6\eta_i\eta_j$, so

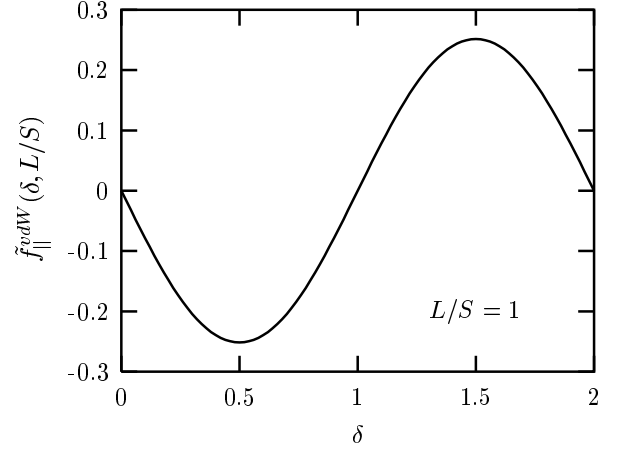


FIG. 26: Scaling function $\tilde{f}_{\parallel}^{vdW}$ of the lateral van der Waals force as a function of the relative shift δ for $L = S$ (see Eqs. (64) and (65)).

that $F_{\parallel}^{vdW}$ vanishes if the chemical contrast disappears, i.e., for $+ = -$; $\tilde{f}_{\parallel}^{vdW}$ is a dimensionless scaling function (see Eq. (A19)):

$$\tilde{f}_{\parallel}^{vdW}\left(\frac{L}{S}, \delta\right) = \frac{15\pi}{16} \sum_{m=-\infty}^{\infty} \int_0^1 d\zeta_1 \int_{\delta+2m}^{\delta+2m+1} d\zeta_2 \frac{\zeta_1 - \zeta_2}{\left[\left(\frac{L}{S}\right)^2 + (\zeta_1 - \zeta_2)^2\right]^{\frac{7}{2}}}. \quad (65)$$

For $L/S = 1$ the scaling function $\tilde{f}_{\parallel}^{vdW}$ (see Fig. 26) attains maximal values of the order of 0.3. We estimate the prefactor E/S^5 as follows. The interaction energy ϵ_{ij} is typically in the order of $\epsilon/k_B = 300K$ (see Table I in Ref. 49), the length σ_{ij} is comparable with the atomic diameters of the interacting particles, $\sigma_{ij} = 0.5$ nm, and in the case of a 2-dimensional closed packing the areal number density η_i of the particles is $\eta_i = \sqrt{3}/(6R_i^2)$, with the radius $R_i = \sigma_{ii}/2$ of the particles. Assuming stripe widths of $S = 100$ nm one has typical values $E_{ij}/S^5 \simeq 5.5 \cdot 10^{-4} \text{ pN}/(\mu\text{m})^2$. Thus the lateral van der Waals force is of the order of $1.7 \cdot 10^{-4} \text{ pN}/(\mu\text{m})^2$. The actual value is smaller due to the differences of $E_{i,j}$ forming E .

According to Eq. (47) the singular lateral force is given by

$$\frac{F_{\parallel}^{ps}(t, L, S, D)}{2NSH} = \frac{(d-1)k_B T_c}{L^d} \tilde{f}_{\parallel}^{ps}\left(\tilde{L}, \frac{S}{L}, \delta\right). \quad (66)$$

For a ratio $S/L = 1$ the scaling function $\tilde{f}_{\parallel}^{ps}$ attains maximal values of the order of $|\Delta_0^{++}|$ (see Fig. 23) with $|\Delta_0^{++}| = 0.32$.³³ For $d = 3$, $T_c = 300$ K, and a separation $L = 100$ nm of the substrates, the critical force is of the

order of $1.3 \text{ pN}/(\mu\text{m})^2$. According to this estimate for ratios $S/L \simeq 1$ the direct lateral van der Waals force due to the chemical patterning is negligible compared with the critical structural force.

IV. SUMMARY

We have studied the singular contributions to the effective forces acting on chemically inhomogeneous substrates which confine a binary liquid mixture near a continuous demixing transition. Geometrically flat and parallel substrates with periodic chemical patterns of positive stripes (surface field $h_1 \rightarrow +\infty$) of width S_+ and negative stripes ($h_1 \rightarrow -\infty$) of width S_- separated by a distance L are considered.

Four basic configurations of the two substrates are studied. First, two substrates exhibiting the same stripe patterns, i.e., a positive stripe opposite of a positive stripe, which we call “++ configuration”, are considered (Fig. 2(a), Subsec. III B). Second, two substrates with opposite stripe patterns, i.e., a positive stripe opposed to a negative one, called the “+- configuration”, are studied (Fig. 2(b), Subsec. III C). This is followed by investigations of the forces between a structured and a homogeneous substrate, called the “ph configuration” (Fig. 2(c), Subsec. III D). For two substrates with the same but misaligned stripe patterns, called the “ps configuration” (Fig. 2(d), Subsec. III D), the normal and lateral forces depend on the misalignment of the surface structures.

The universal behavior of the order parameter profiles and of the effective forces acting between the substrates is determined by universal scaling functions (Eqs. (44) - (47)). In order to obtain explicit results for these scaling functions the order parameter profiles are calculated numerically within mean field theory from which the forces between the plates are derived via the stress tensor (Eqs. (49) - (51), (52) - (54)).

The scaling function of the force between two periodically structured substrates in the ++ configuration depends on the scaled distance $\tilde{L} = L/\xi$ between the substrates, where ξ is the bulk correlation length, as well as on the ratio S_-/S_+ of the stripe widths (Figs. 3 and 5) and the ratio S_+/L (Fig. 4). In order to obtain well-defined mean field values for the spatial dimension $d = 4$ the scaling functions of the force between structured substrates are expressed in units of the universal Casimir amplitude Δ_0^{++} characterizing the scaling function of the force between homogeneous substrates with parallel surface fields (Fig. 1 and Eq. (40)). In the limit $S_-/S_+ \rightarrow 0$ and $S_-/S_+ \rightarrow \infty$ with fixed ratio S_+/L the scaling function of the patterned substrates approaches the scaling function of the homogeneous substrates. This limiting case is also reached for an increasing ratio S_+/L .

At the critical point the force is determined by a universal scaling function of the scaling variables S_-/S_+ and S_+/L , which reduces to the Casimir amplitude Δ_0^{++}

in the limits $S_-/S_+ \rightarrow 0$ and $S_-/S_+ \rightarrow \infty$ (Fig. 6). The limit $L \rightarrow \infty$ of this scaling function can be interpreted as a generalized Casimir amplitude $\Delta^{++}(S_-/S_+)$. Thus the chemical patterning of the substrates allows one to tune the universal Casimir amplitude within a finite range of negative values (Fig. 6).

The force between two periodically structured substrates in the +- configuration is governed by a scaling function which depends on the same scaling variables $\tilde{L}$, S_-/S_+ (Figs. 7 and 9), and S_+/L (Fig. 8). Like for the ++ configuration it is reduced compared to the scaling function of the force between two homogeneous substrates with antiparallel surface fields. Analogously to the ++ configuration, the scaling function of the +- configuration attains the scaling function of the homogeneous substrates in the limits $S_-/S_+ \rightarrow 0$ and $S_-/S_+ \rightarrow \infty$ with a fixed ratio S_+/L and in the limit $S_+/L \rightarrow \infty$ for a fixed ratio S_-/S_+ .

As in the case of the ++ configuration, a generalized Casimir amplitude $\Delta^{+-}(S_-/S_+)$ can be defined also for the +- configuration. This follows from the universal scaling function describing the force at T_c which depends on the scaling variables S_-/S_+ and S_+/L . In the limits $S_-/S_+ \rightarrow 0$ and $S_-/S_+ \rightarrow \infty$ it reduces to the Casimir amplitude $\Delta_0^{+-} > 0$ (Eq. (41)) characterizing the force between homogeneous substrates with antiparallel surface fields (Fig. 10). Here the chemical patterning allows to tune the universal Casimir amplitude within a finite range of positive values (Fig. 10). The ratio of the generalized Casimir amplitudes for the +- and the ++ configuration as function of S_-/S_+ is shown in Fig. 17.

The ph configuration of a critical fluid confined between a periodically patterned and a homogeneous substrate with positive surface field interpolates, as a function of the ratio S_-/S_+ of the stripe widths, between the case of two homogeneous substrates with parallel surface fields ($S_-/S_+ \rightarrow 0$) and the case of two homogeneous substrates with antiparallel surface fields ($S_-/S_+ \rightarrow \infty$) (Fig. 11, Figs. 13 - 15). Accordingly the corresponding generalized Casimir amplitude $\Delta^{ph}(S_-/S_+)$ interpolates between the Casimir amplitude $\Delta_0^{++} < 0$ at $S_-/S_+ = 0$ and the Casimir amplitude $\Delta_0^{+-} > 0$ at $S_-/S_+ \rightarrow \infty$. Figure 12 shows universal scaling functions at T_c for non-vanishing ratios S_+/L , which converge to the generalized Casimir amplitude $\Delta^{ph}(S_-/S_+)$ in the limit $S_+/L \rightarrow 0$. In this case the chemical patterning allows one to tune even the sign of the Casimir amplitude and to drive the leading critical Casimir force to zero. This opens the possibility to observe the leading correction term which is typically masked by the dominant term.

The absolute value of the scaling function of the force between substrates in the ++ configuration is smaller than the corresponding one for the +- configuration

(Fig. 16). In the case of very narrow stripes, i.e., for $S_+/L \ll 1$ (Figs. 16(b) and (d)) the absolute value of the scaling function of the ph configuration is significantly larger than the one for the $++$ configuration and the one for the $+-$ configuration. The reason for this is that the surface fields of the structured substrates effectively tend to zero for decreasing stripe widths – mimicking Dirichlet boundary conditions – whereas the surface field of the homogeneous substrate of the ph configuration remains finite.

If the structures of the patterned substrates are not in phase but shifted relative to each other, an additional lateral force emerges which acts as to restore a configuration in which the structures are again in phase. In this ps configuration the scaling functions of the force depend additionally on the relative shift $\delta = D/S$ of the stripes of one substrate with respect to the stripes of the other substrate (Fig. 2(d)). In order to limit the number of the relevant length scales here we have chosen $S_- = S_+ = S$. The scaling function of the normal force as a function of the relative shift δ transfers the scaling function for the $++$ configuration for $\delta = 0$ into the scaling function for the $+-$ configuration for $\delta = 1$ (Figs. 18 and 20).

The importance of the relative shift δ decreases with increasing scaled distance $\tilde{L}$ between the substrates. The influence of the scaled stripe width $\tilde{S} = S/\xi$ is visible through the dependence of the scaling function on the ratio L/S (Fig. 19) with the conclusion that the scaling function does not reduce to an effective scaling function of only the two variables L/S and δ .

The generalized Casimir amplitude $\Delta^{ps}(S/L, \delta)$, characterizing the scaling function of the normal force at the critical temperature (Fig. 21), vanishes in the limit $S/L \rightarrow 0$. For positive and negative stripes of the same width, in this limit the surface field effectively tends to zero corresponding to Dirichlet (ordinary) boundary conditions for which the force vanishes within mean field theory.

Figures 6, 10, 12, and 21 demonstrate the tunability of the Casimir amplitudes via the chemical patterning of the substrates. The fact that within mean field theory the Casimir amplitudes $\Delta^{++}(S_-/S_+, S_+/L)$, $\Delta^{+-}(S_-/S_+, S_+/L)$, and $\Delta^{ps}(\delta, S/L)$ vanish for $S_+/S_- = 1$ in the limit $S_+/L \rightarrow 0$ and $S/L \rightarrow 0$, respectively, resembling Dirichlet boundary conditions, is remarkable. In general in classical fluid systems the substrate potential breaks the symmetry of the order parameter such that these systems are unable to exhibit Dirichlet boundary conditions. Only in the case of quantum fluids, i.e., in critical superfluid He^4 films, Dirichlet boundary conditions show up.^{32,50} The results shown in Figs. 6, 10, 12, and 21 visualize that for suitably chosen chemical patterns Dirichlet boundary conditions effectively emerge even for classical fluids.

The scaling function of the lateral force vanishes for rela-

tive shifts $\delta = 0$, $\delta = 1$, and $\delta = 2$ (Figs. 22 and 23). For shifts $0 < \delta < 1$ the scaling function of the lateral force is negative, i.e., restoring. For $1 < \delta < 2$ it is positive, i.e., the force acts into the direction of the shift. For $\delta = 1$ the scaling function exhibits an inflection point, which means that the corresponding $+-$ configuration is an unstable configuration.

The free energy required to shift the patterned substrates relative to each other (Eq. (62)) is given by a scaling function (Eq. (63) and Fig. 24) which shows a maximum at $D \simeq S$ and exhibits inflection points at $D/S = 0.5$ and $D/S = 1.5$ corresponding to the occurrence of maximal forces. The maximum of this free energy, i.e., the activation energy needed to move a system from a $++$ configuration to the adjacent $+-$ configuration via shifting the substrates by $D = S$, depends on the distance between the substrates and vanishes for increasing distances (Fig. 25).

The background contribution from direct van der Waals forces (Fig. 26), generated by the chemical patterning within a monolayer covering the substrates, is negligible for ratios $S/L \simeq 1$ compared with the critical lateral force.

APPENDIX A: LATERAL VAN DER WAALS FORCE

The lateral van der Waals force $F_{\parallel}^{vdW} = -\frac{\partial U_{\parallel}^{vdW}}{\partial D}$ is generated by the direct interaction between the two substrate species forming the chemical pattern. Here we assume that this chemical pattern is confined to a monolayer and that the corresponding pair potentials are given by Lennard-Jones potentials:

$$U_{ij} = 4\epsilon_{ij} \left[\left(\frac{\sigma_{ij}}{r} \right)^{12} - \left(\frac{\sigma_{ij}}{r} \right)^6 \right], \quad i, j \in \{+, -\}. \quad (\text{A1})$$

Since $L \gg \sigma_{ij}$, for the lateral van der Waals force only the attractive part of the Lennard-Jones potentials is important. Assuming pairwise additivity the leading contribution to $U_{\parallel}^{vdW}$ is given by:⁵¹

$$U_{\parallel}^{vdW} = - \int_{S_1} dx_1 dy_1 \int_{S_2} dx_2 dy_2 \frac{E(x_1, x_2, D)}{[L^2 + (x_1 - x_2)^2 + (y_1 - y_2)^2]^3}, \quad (\text{A2})$$

with x_1 and x_2 denoting the direction of the inhomogeneity on the substrate S_1 and S_2 , respectively, and y_1 and y_2 the directions perpendicular to it (see Fig. 2). Depending on the lateral position, $E(x_1, x_2, D)$ equals E_{++} , E_{+-} , or E_{--} (see, c.f., Eqs. (A6) and (A8)). The contributions E_{ij} are given by $E_{ij} = 4\epsilon_{ij}\sigma_{ij}^6\eta_i\eta_j$, where η_i denote the areal number densities of the particles.

In order to carry out the quadruple integral in Eq. (A2) we first consider the interaction $U_{\parallel, S_+}^{vdW}$ of a positive stripe

on the substrate S_1 of width S and extension H in the y_1 direction with the whole substrate S_2 with infinite extensions in the x_2 and y_2 directions:

$$U_{\parallel, S_+}^{vdW} = - \int_0^S dx_1 \int_0^H dy_1 \int_{-\infty}^{\infty} dx_2 \int_{-\infty}^{\infty} dy_2 \frac{E(x_1, x_2, D)}{[L^2 + (x_1 - x_2)^2 + (y_1 - y_2)^2]^3}. \quad (\text{A3})$$

With

$$\int_{-\infty}^{+\infty} dx \frac{1}{(a^2 + x^2)^3} = \frac{3\pi}{8a^5} \quad (\text{A4})$$

Eq. (A3) gives

$$U_{\parallel, S_+}^{vdW} = - \frac{3\pi}{8} H \int_0^S dx_1 \int_{-\infty}^{\infty} dx_2 \frac{E(x_1, x_2, D)}{[L^2 + (x_1 - x_2)^2]^{\frac{5}{2}}}. \quad (\text{A5})$$

The integration over the x_2 direction can be split up into integrations over the stripes of the substrates S_2 , for which the strength $E(x_1, x_2, D)$ of the interaction is constant:

$$\begin{aligned} x_1 \in [0, S], x_2 \in [D + 2mS, D + (2m + 1)S] : \\ E(x_1, x_2, D) = E_{++} \\ x_1 \in [0, S], x_2 \in [D + (2m + 1)S, D + (2m + 2)S] : \\ E(x_1, x_2, D) = E_{+-}, \end{aligned} \quad (\text{A6})$$

where $m \in \mathbb{Z}$. Thus one has for $U_{\parallel, S_+}^{vdW}$ (Eq. (A5)):

$$\begin{aligned} U_{\parallel, S_+}^{vdW} = - \frac{3\pi}{8} H \sum_{m=-\infty}^{\infty} \\ \left(\int_0^S dx_1 \int_{D+2mS}^{D+(2m+1)S} dx_2 \frac{E_{++}}{[L^2 + (x_1 - x_2)^2]^{\frac{5}{2}}} \right. \\ \left. + \int_0^S dx_1 \int_{D+(2m+1)S}^{D+(2m+2)S} dx_2 \frac{E_{+-}}{[L^2 + (x_1 - x_2)^2]^{\frac{5}{2}}} \right). \end{aligned} \quad (\text{A7})$$

Now we consider the interaction energy $U_{\parallel, S_-}^{vdW}$ of a negative stripe on the substrate S_1 of width S and extension H in the y_1 direction with the whole substrate S_2 with infinite extensions in x_2 and y_2 direction. The strength of the interaction is given by

$$\begin{aligned} x_1 \in [S, 2S], x_2 \in [D + 2mS, D + (2m + 1)S] : \\ E(x_1, x_2, D) = E_{+-} \\ x_1 \in [S, 2S], x_2 \in [D + (2m + 1)S, D + (2m + 2)S] : \\ E(x_1, x_2, D) = E_{--}, \end{aligned} \quad (\text{A8})$$

such that $U_{\parallel, S_-}^{vdW}$ is described by:

$$\begin{aligned} U_{\parallel, S_-}^{vdW} = - \frac{3\pi}{8} H \sum_{m=-\infty}^{\infty} \\ \left(\int_S^{2S} dx_1 \int_{D+2mS}^{D+(2m+1)S} dx_2 \frac{E_{+-}}{[L^2 + (x_1 - x_2)^2]^{\frac{5}{2}}} \right. \\ \left. + \int_S^{2S} dx_1 \int_{D+(2m+1)S}^{D+(2m+2)S} dx_2 \frac{E_{--}}{[L^2 + (x_1 - x_2)^2]^{\frac{5}{2}}} \right). \end{aligned} \quad (\text{A9})$$

The sum of the interaction energies $U_{\parallel, S_+}^{vdW}$ (Eq. (A7)) and $U_{\parallel, S_-}^{vdW}$ (Eq. (A9)) is

$$\begin{aligned} U_{\parallel, S_+}^{vdW} + U_{\parallel, S_-}^{vdW} = - \frac{3\pi}{8} H \sum_{m=-\infty}^{\infty} \\ \left(\int_{D+2mS}^{D+(2m+1)S} dx_2 \left(\int_0^S dx_1 \frac{E_{++}}{[L^2 + (x_1 - x_2)^2]^{\frac{5}{2}}} \right. \right. \\ \left. \left. + \int_S^{2S} dx_1 \frac{E_{+-}}{[L^2 + (x_1 - x_2)^2]^{\frac{5}{2}}} \right) \right. \\ \left. + \int_{D+(2m+1)S}^{D+(2m+2)S} dx_2 \left(\int_0^S dx_1 \frac{E_{+-}}{[L^2 + (x_1 - x_2)^2]^{\frac{5}{2}}} \right. \right. \\ \left. \left. + \int_S^{2S} dx_1 \frac{E_{--}}{[L^2 + (x_1 - x_2)^2]^{\frac{5}{2}}} \right) \right) \\ = - \frac{3\pi}{8} H \sum_{m=-\infty}^{\infty} \\ \left(\int_{D+2mS}^{D+(2m+1)S} dx_2 \int_0^S dx_1 \frac{E_{++} - E_{+-}}{[L^2 + (x_1 - x_2)^2]^{\frac{5}{2}}} \right. \\ \left. + \int_{D+2mS}^{D+(2m+1)S} dx_2 \int_0^{2S} dx_1 \frac{E_{+-}}{[L^2 + (x_1 - x_2)^2]^{\frac{5}{2}}} \right. \\ \left. + \int_{D+(2m+1)S}^{D+(2m+2)S} dx_2 \int_S^{2S} dx_1 \frac{E_{--} - E_{+-}}{[L^2 + (x_1 - x_2)^2]^{\frac{5}{2}}} \right. \\ \left. + \int_{D+(2m+1)S}^{D+(2m+2)S} dx_2 \int_0^{2S} dx_1 \frac{E_{+-}}{[L^2 + (x_1 - x_2)^2]^{\frac{5}{2}}} \right). \end{aligned} \quad (\text{A10})$$

The transformation $X_1 = x_1 - S_+$ and $X_2 = x_2 - S_+$ in the third term renders:

$$\begin{aligned} U_{\parallel, S_+}^{vdW} + U_{\parallel, S_-}^{vdW} = - \frac{3\pi}{8} H \sum_{m=-\infty}^{\infty} \\ \left(\int_{D+2mS}^{D+(2m+1)S} dx_2 \int_0^S dx_1 \frac{E_{++} - 2E_{+-} + E_{--}}{[L^2 + (x_1 - x_2)^2]^{\frac{5}{2}}} \right. \\ \left. + \int_{D+2mS}^{D+(2m+2)S} dx_2 \int_0^{2S} dx_1 \frac{E_{+-}}{[L^2 + (x_1 - x_2)^2]^{\frac{5}{2}}} \right). \end{aligned} \quad (\text{A11})$$

Scaling the lengths with the stripe width S ,

$$\zeta_1 = \frac{x_1}{S}, \quad \zeta_2 = \frac{x_2}{S}, \quad \delta = \frac{D}{S}, \quad (\text{A12})$$

leads to

$$\begin{aligned} U_{\parallel, S_+}^{vdW} + U_{\parallel, S_-}^{vdW} = & -\frac{3\pi}{8} \frac{H}{S^3} \sum_{m=-\infty}^{\infty} \left(\int_{\delta+2m}^{\delta+(2m+1)} d\zeta_2 \int_0^1 d\zeta_1 \frac{E_{++} - 2E_{+-} + E_{--}}{\left[\left(\frac{L}{S}\right)^2 + (\zeta_1 - \zeta_2)^2\right]^{\frac{5}{2}}} \right. \\ & \left. + \int_{\delta+2m}^{\delta+(2m+2)} d\zeta_2 \int_0^2 d\zeta_1 \frac{E_{+-}}{\left[\left(\frac{L}{S}\right)^2 + (\zeta_1 - \zeta_2)^2\right]^{\frac{5}{2}}} \right). \end{aligned} \quad (\text{A13})$$

$$\begin{aligned} & \sum_{m=-\infty}^{\infty} \int_{\delta+2m}^{\delta+(2m+2)} d\zeta_2 \int_0^2 d\zeta_1 \frac{E_{+-}}{\left[\left(\frac{L}{S}\right)^2 + (\zeta_1 - \zeta_2)^2\right]^{\frac{5}{2}}} \\ & = \lim_{m \rightarrow \infty} \int_{\delta-2m}^{\delta+(2m+2)} d\zeta_2 \int_0^2 d\zeta_1 \frac{E_{+-}}{\left[\left(\frac{L}{S}\right)^2 + (\zeta_1 - \zeta_2)^2\right]^{\frac{5}{2}}}. \end{aligned} \quad (\text{A14})$$

The interaction energy $U_{\parallel}^{vdW}/N$ of a positive and a negative stripe on one substrate, where N is the number of repeat units, with the structure on the other substrate per area $2SH$ reads

$$\begin{aligned} \frac{U_{\parallel}^{vdW}}{2NSH} = & -\frac{3\pi}{16} \frac{E}{S^4} \sum_{m=-\infty}^{\infty} \int_0^1 d\zeta_1 \int_{\delta+2m}^{\delta+2m+1} d\zeta_2 \frac{1}{\left[\left(\frac{L}{S}\right)^2 + (\zeta_1 - \zeta_2)^2\right]^{\frac{5}{2}}} \\ & - \frac{3\pi}{16} \frac{E_{+-}}{S^4} \lim_{m \rightarrow \infty} \int_0^2 d\zeta_1 \int_{\delta-2m}^{\delta+(2m+2)} d\zeta_2 \frac{1}{\left[\left(\frac{L}{S}\right)^2 + (\zeta_1 - \zeta_2)^2\right]^{\frac{5}{2}}}, \end{aligned} \quad (\text{A15})$$

where $E = E_{++} - 2E_{+-} + E_{--}$.

The lateral van der Waals force is determined by the derivative of $U_{\parallel}^{vdW}$ with respect to the shift D :

$$\begin{aligned} \frac{F_{\parallel}^{vdW}}{2NSH} = & -\frac{1}{2NSH} \frac{\partial U_{\parallel}^{vdW}}{\partial D} = \frac{3\pi}{16} \frac{E}{S^5} \sum_{m=-\infty}^{\infty} \frac{\partial}{\partial \delta} \int_0^1 d\zeta_1 \int_{\delta+2m}^{\delta+2m+1} d\zeta_2 \frac{1}{\left[\left(\frac{L}{S}\right)^2 + (\zeta_1 - \zeta_2)^2\right]^{\frac{5}{2}}} \\ & + \frac{3\pi}{16} \frac{E_{+-}}{S^5} \lim_{m \rightarrow \infty} \frac{\partial}{\partial \delta} \left\{ \int_0^2 d\zeta_1 \int_{\delta-2m}^{\delta+(2m+2)} d\zeta_2 \frac{1}{\left[\left(\frac{L}{S}\right)^2 + (\zeta_1 - \zeta_2)^2\right]^{\frac{5}{2}}} \right\} \\ = & \frac{15\pi}{16} \frac{E}{S^5} \sum_{m=-\infty}^{\infty} \int_0^1 d\zeta_1 \int_{\delta+2m}^{\delta+2m+1} d\zeta_2 \frac{\zeta_1 - \zeta_2}{\left[\left(\frac{L}{S}\right)^2 + (\zeta_1 - \zeta_2)^2\right]^{\frac{7}{2}}} \\ & + \frac{15\pi}{16} \frac{E_{+-}}{S^5} \lim_{m \rightarrow \infty} \int_0^2 d\zeta_1 \int_{\delta-2m}^{\delta+(2m+2)} d\zeta_2 \frac{\zeta_1 - \zeta_2}{\left[\left(\frac{L}{S}\right)^2 + (\zeta_1 - \zeta_2)^2\right]^{\frac{7}{2}}}. \end{aligned} \quad (\text{A16})$$

The last term in Eq. (A16) vanishes:

$$\lim_{m \rightarrow \infty} \int_0^2 d\zeta_1 \int_{\delta-2m}^{\delta+(2m+2)} d\zeta_2 \frac{\zeta_1 - \zeta_2}{\left[\left(\frac{L}{S}\right)^2 + (\zeta_1 - \zeta_2)^2\right]^{\frac{7}{2}}} = 0. \quad (\text{A17})$$

Therefore the lateral van der Waals force $F_{\parallel}^{vdW}$ per area $2NSH$ between two structured monolayers is given by

$$\frac{F_{\parallel}^{vdW}}{2NSH} = \frac{E}{S^5} \tilde{f}_{\parallel}^{vdW} \quad (\text{A18})$$

with the scaling function

$$\tilde{f}_{\parallel}^{vdW} = \frac{15\pi}{16} \sum_{m=-\infty}^{\infty} \int_0^1 d\zeta_1 \int_{\delta+2m}^{\delta+2m+1} d\zeta_2 \frac{\zeta_1 - \zeta_2}{\left[\left(\frac{L}{S}\right)^2 + (\zeta_1 - \zeta_2)^2\right]^{\frac{7}{2}}}. \quad (\text{A19})$$

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- ¹ F. S. Bates, *Science* **251**, 898 (1991).
 - ² G. Krausch and R. Magerle, *Adv. Mat.* **14**, 1579 (2002).
 - ³ M. Böltau, S. Walheim, J. Mlynek, G. Krausch, and U. Steiner, *Nature* **391**, 877 (1998).
 - ⁴ A. Kumar and G.M. Whitesides, *Appl. Phys. Lett.* **63**, 2002 (1993).
 - ⁵ Y. Xia, J. A. Rogers, K.E. Paul, and G.M. Whitesides, *Chem. Rev.* **99**, 1823 (1999).
 - ⁶ B. Zhao, J. S. Moore, and D. J. Beebe, *Anal. Chem.* **74**, 4259 (2002).
 - ⁷ R. Wang, K. Hashimoto, A. Fujishima, M. Chikuni, E. Kojima, A. Kitamura, M. Shimohigoshi, and T. Watanabe, *Nature* **388**, 431 (1997).
 - ⁸ R. Wang, K. Hashimoto, A. Fujishima, M. Chikuni, E. Kojima, A. Kitamura, M. Shimohigoshi, and T. Watanabe, *Adv. Mat.* **10**, 135 (1998).
 - ⁹ K. Seki and M. Tachiya, *J. Phys. Chem. B* **108**, 4806 (2004).
 - ¹⁰ T. Thorsen, S.J. Maerkl, and S.R. Quake, *Science* **298**, 580 (2002).
 - ¹¹ D. Juncker, H. Schmidt, U. Drechsler, H. Wolf, M. Wolf, B. Michel, N. de Rooij, and E. Delamarche, *Anal. Chem.* **74**, 6139 (2002).
 - ¹² C. Bauer, S. Dietrich, and A.O. Parry, *Europhys. Lett.* **47**, 474 (1999).
 - ¹³ C. Bauer and S. Dietrich, *Phys. Rev. E* **60**, 6919 (1999).
 - ¹⁴ M. Brinkmann and R. Lipowsky, *J. Appl. Phys.* **92**, 4296 (2002).
 - ¹⁵ M. Schneemilch, N. Quirke, and J.R. Henderson, *J. Chem. Phys.* **118**, 816 (2003).
 - ¹⁶ M. Sprenger, F. Schlesener, and S. Dietrich, *Phys. Rev. E* **71**, 056125 (2005).
 - ¹⁷ S. Kondrat, A. Poniewierski, and L. Harnau, *Liquid Crystals* **32**, 95 (2005).
 - ¹⁸ Q. Wang, *Macromol. Theory Simul.* **14**, 96 (2005).
 - ¹⁹ Y. Tsori and D. Andelman, *Europhys. Lett.* **53**, 722 (2001).
 - ²⁰ Y. Tsori and D. Andelman, *Macromolecules* **34**, 27190 (2001).
 - ²¹ Y. Tsori and D. Andelman, *Interface Science* **11**, 259 (2003).
 - ²² D.J. Diestler, M. Schoen, J.E. Curry, and J.H. Cushman, *J. Chem. Phys.* **100**, 9140 (1994).
 - ²³ H. Bock and M. Schoen, *J. Phys.: Condens. Matter* **12**, 1545 (2000).
 - ²⁴ H. Bock, D.J. Diestler, and M. Schoen, *J. Phys.: Condens. Matter* **13**, 4697 (2001).
 - ²⁵ H. Bock, D.J. Diestler, and M. Schoen, *Phys. Rev. E* **64**, 046124 (2001).
 - ²⁶ H. Greberg and G.N. Patey, *J. Chem. Phys.* **114**, 7182 (2001).
 - ²⁷ S.D. Overduin and G.N. Patey, *J. Chem. Phys.* **117**, 3391 (2002).
 - ²⁸ H.B.G. Casimir, *Proc. Koninkl. Ned. Akad. Wetenschap*, **BS1**, 793 (1948).
 - ²⁹ M.E. Fisher and P.-G. de Gennes, *Compt. Rend. Acad. Sci. B* **287**, 207 (1978).
 - ³⁰ M. Krech and S. Dietrich, *Phys. Rev. Lett.* **66**, 345 (1991); **67**, 1055 (1991).
 - ³¹ M. Krech and S. Dietrich, *Phys. Rev. A* **46**, 1886 (1992).
 - ³² M. Krech and S. Dietrich, *Phys. Rev. A* **46**, 1922 (1992).
 - ³³ M. Krech, *Phys. Rev. E* **56**, 1642 (1997).
 - ³⁴ F. Karimi Pour Haddadan, F. Schlesener, and S. Dietrich, *Phys. Rev. E* **70**, 041701 (2004).
 - ³⁵ H.W. Diehl, in *Phase Transitions and Critical Phenomena*, edited by C. Domb and J. L. Lebowitz (Academic, London, 1986), Vol. 10, p. 75.
 - ³⁶ K. Binder, in *Phase Transitions and Critical Phenomena*, edited by C. Domb and J. L. Lebowitz (Academic, London, 1983), Vol. 8, p. 1.
 - ³⁷ T.C. Lubensky and M.H. Rubin, *Phys. Rev. B* **11**, 4533 (1975).
 - ³⁸ Y. Okabe and K. Ohno, *Phys. Rev. B* **30**, 6573 (1984).
 - ³⁹ A.J. Bray and M.A. Moore, *J. Phys. A* **10**, 1927 (1977).
 - ⁴⁰ T.W. Burkhardt and H.W. Diehl, *Phys. Rev. B* **50**, 3894 (1994).
 - ⁴¹ J.O. Indekeu, M.P. Nightingale, and W.V. Wang, *Phys. Rev. B* **34**, 330 (1986).
 - ⁴² E. Stanley, *Phase Transitions and Critical Phenomena*, Oxford University Press (1971).
 - ⁴³ B.J. Schulz, K. Binder, and H. Müller, *Phys. Rev. E* **71**, 046705 (2005).
 - ⁴⁴ M.E. Fisher and H. Au-Yang, *Physica A* **101**, 255 (1980).
 - ⁴⁵ M.E. Fisher and H. Nakanishi, *J. Chem. Phys.* **75**, 5857 (1981).
 - ⁴⁶ J.C. Collins, *Phys. Rev. D* **14**, 1965 (1976).
 - ⁴⁷ L.S. Brown, *Ann. Phys.* **126**, 135 (1980).
 - ⁴⁸ M. Fukuto, Y.F. Yano, and P.S. Pershan, *Phys. Rev. Lett.* **94**, 135702 (2005).
 - ⁴⁹ T. Getta and S. Dietrich, *Phys. Rev. E* **47**, 1856 (1993).
 - ⁵⁰ R. Garcia and M. H. W. Chan, *Phys. Rev. Lett.* **83**, 1187 (1999).
 - ⁵¹ F. Karimi Pour Haddadan and S. Dietrich, e-print, cond-mat/0512217; the notations have to be translated according to: $L \rightarrow d$, $S \rightarrow \zeta/2$, $D \rightarrow \delta$, $\zeta_1 \rightarrow X_2$, $\zeta_2 \rightarrow X_1$.